



# *Experimental Study on Clearing Electrode at KEKB Positron Ring*

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1. Introduction
2. Experimental Setup
  1. Electrode
  2. Electron Monitor
  3. Test Chamber
3. Results
  1. In Field-Free Region
  2. In Magnet
4. Problems
5. Summary

# Introduction

- Clearing Electrode = **A possible solution to suppress electron cloud in magnets.**
  - Drift space :Solenoid is available.
  - Drastic reduction in EC was indicated by simulations.
- Experimental study on a clearing electrode using KEKB positron ring is planned, as a chain of ILC DR R&D study.
- Goal
  - **Developing a clearing electrode with low beam impedance, and available for high current machine.**
  - **Demonstrate the effect of electrode on electron cloud formation.**

# Introduction

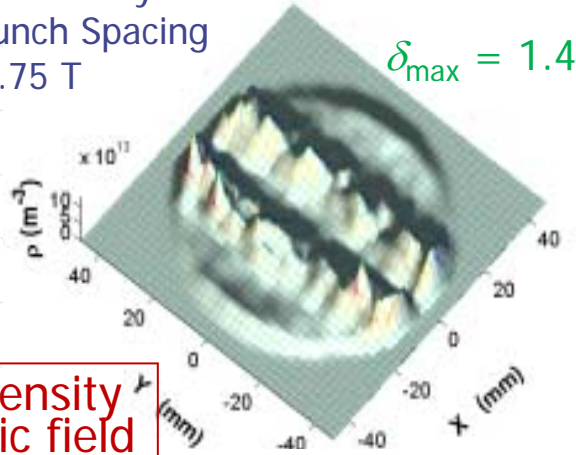
- Simulation

R-pipe=38mm

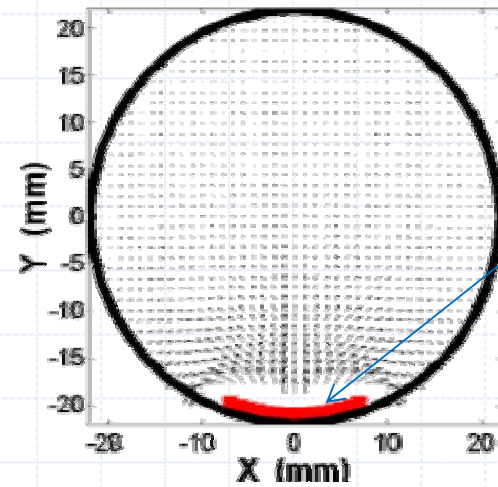
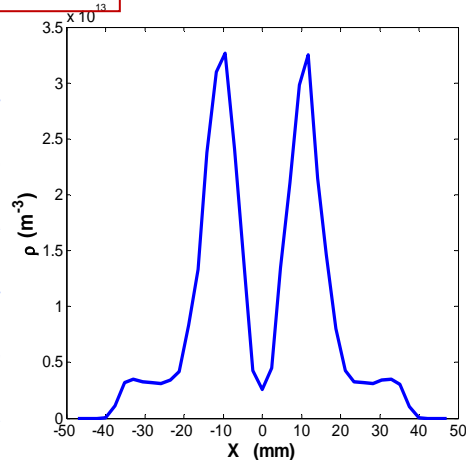
bunch intensity= $9.36 \times 10^{10}$

3.5 Bunch Spacing

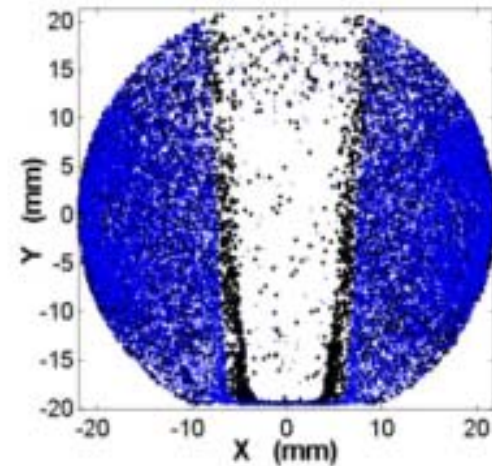
B = 0.75 T



Electron density  
in magnetic field



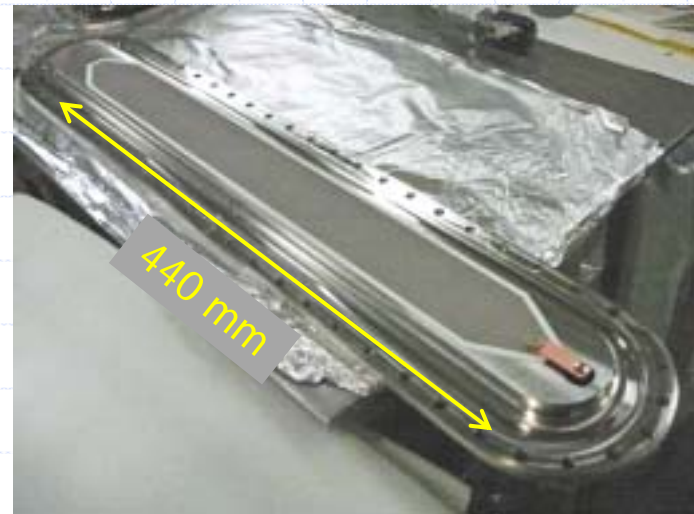
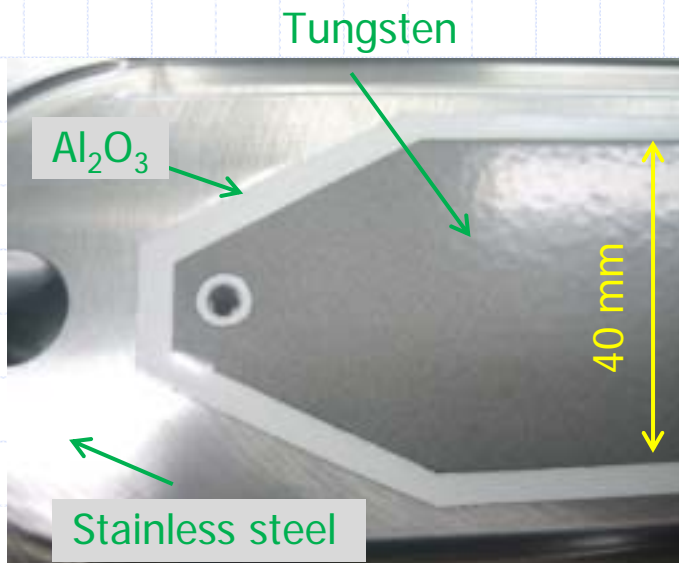
Electrode  
(+)



L. Wang et al, EPAC2006, p.1489

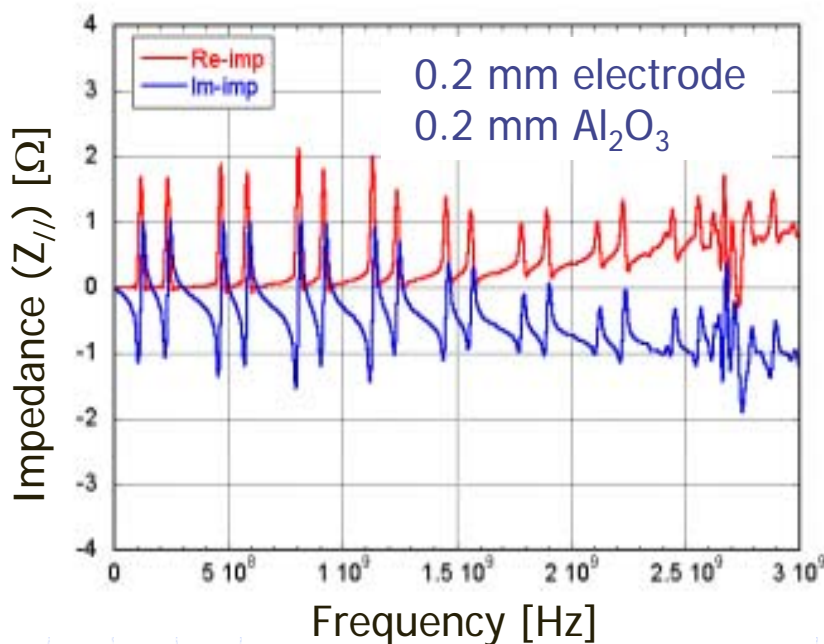
# Electrode

- New strip type electrode was developed.
- **Very thin electrode and insulator;**
  - Electrode: **~0.1 mm**, Tungsten, by thermal spray.
  - Insulator: **~0.2 mm**,  $\text{Al}_2\text{O}_3$ , by thermal spray.

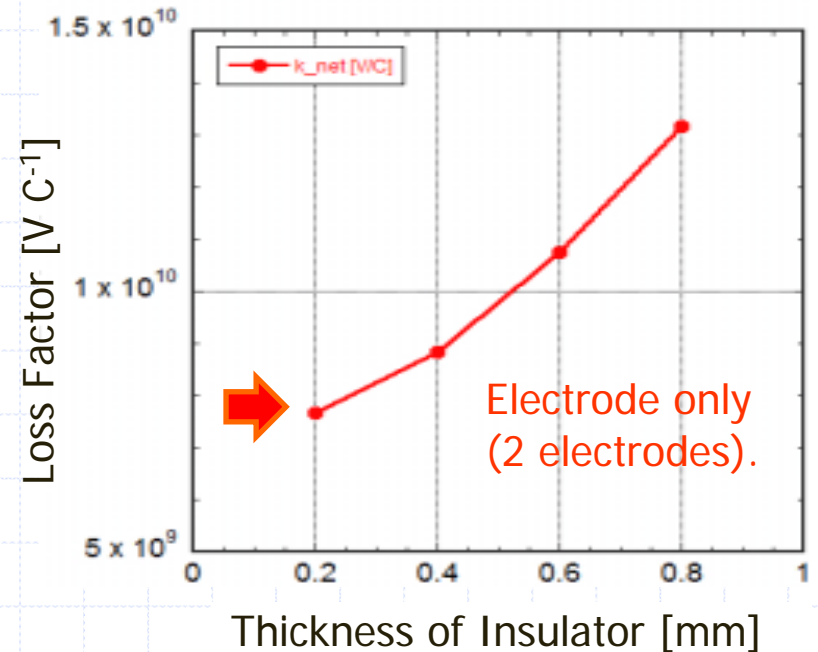


# Electrode

- RF properties (calculation by MAFIA)
  - Thin electrode and insulator  $\rightarrow$  Low beam impedance



- $Z_{//} \sim$  a few Ohm
- $Z_{//}$  reduced to  $\sim 1/5$  compared to the case of 1 mm thick.
- $R/Q \sim 0.1$

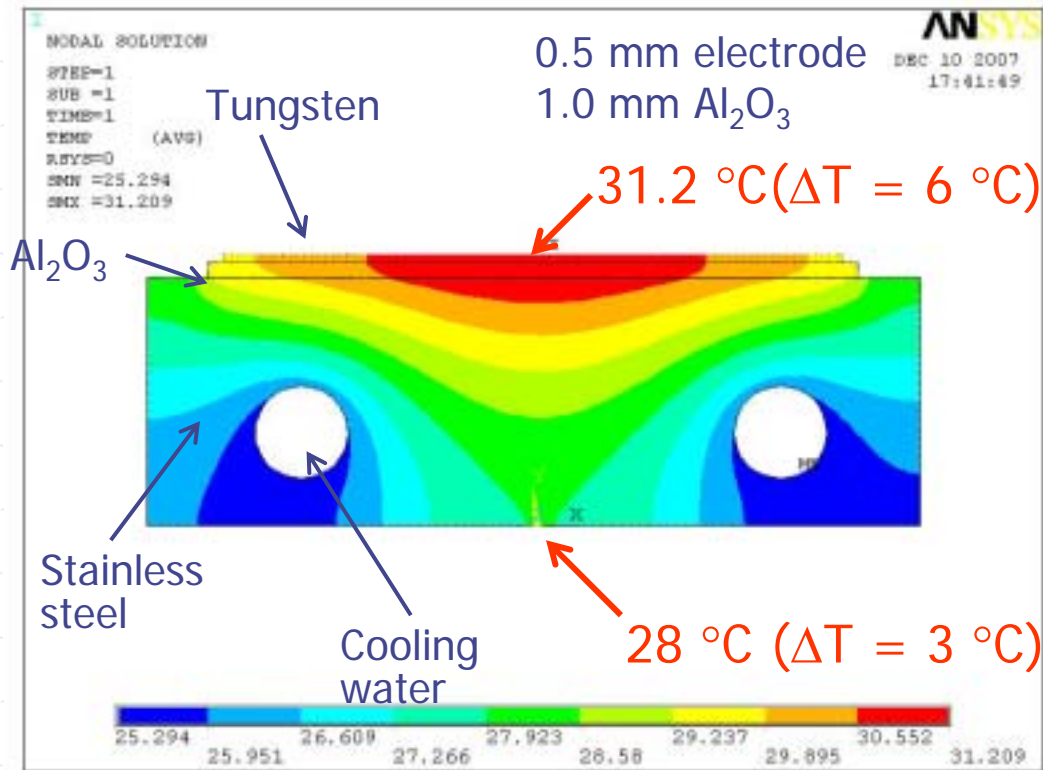


- $k \sim 1.5 \times 10^{10}$  V/C including the connection part (2 electrodes).
- Dissipated power is  $\sim 120$  W for 1 electrode. (@1.6 A, 1585 bunches)



# Electrode

- Heating (simulation by ANSYS)
  - Expected T for 100 W input



- $\Delta T \sim 6$  °C owing to good thermal conductivity between the electrode and chamber.

Heat transfer coefficient between chamber and water =  $0.01 \text{ W mm}^{-2}\text{K}^{-1}$

Temperature of water = 25 degrees.

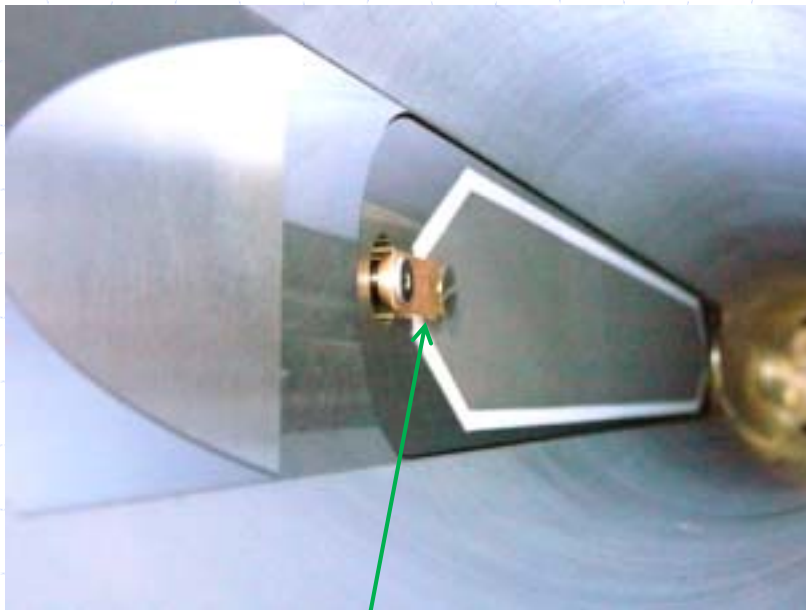
$\lambda(\text{SS}) = 0.017 \text{ W mm}^{-1}\text{K}^{-1}$

$\lambda(\text{Al}_2\text{O}_3) = 0.03 \text{ W mm}^{-1}\text{K}^{-1}$

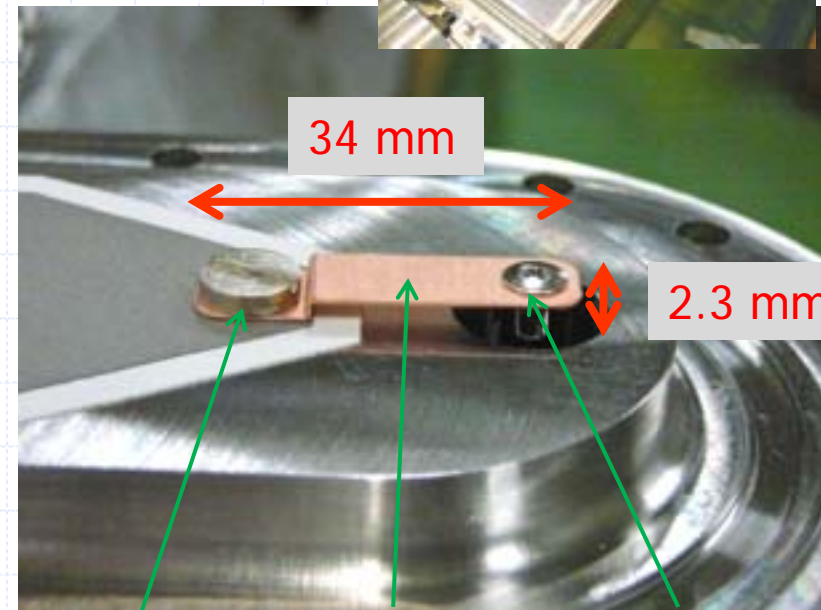
# Electrode

- Assembly to the chamber and connection part
  - The chamber can be baked up to 140 °C.

N-type co-axial connector (~50Ω)



Connection to feed-through



Metal-coated  
 $\text{Al}_2\text{O}_3$  screw

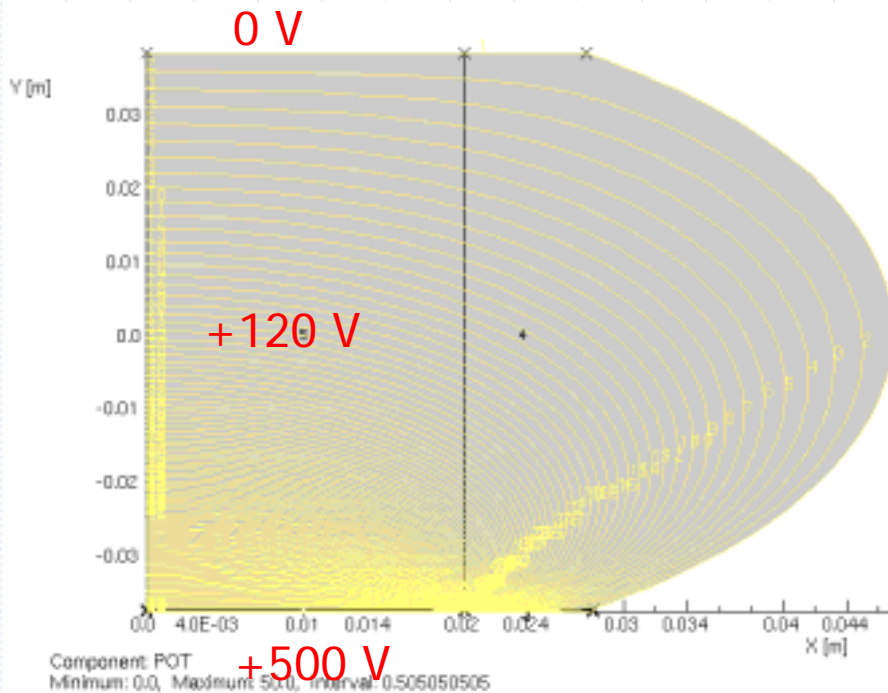
Copper  
bridge

Metal  
screw

# Electrode

- Notes

- Potential distribution

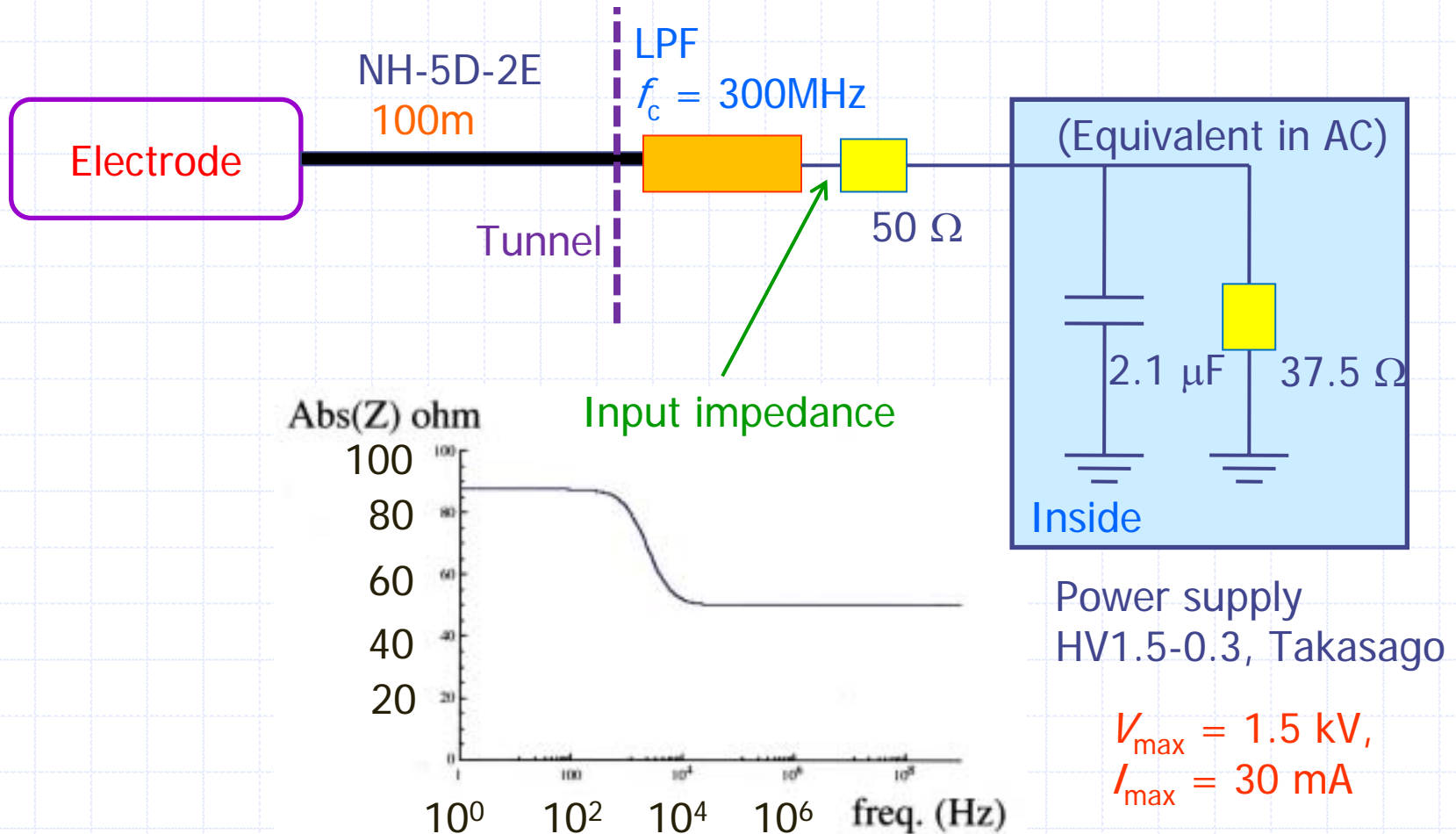


- Similar structure to “Invisible Electrode” by F. Caspers (PAC07).
- Difference: Electrode is made of pure metal (W).
- We used pure metal:
  - (1) To avoid Joule loss of the electrode due to high current
  - (2) To reduce voltage drop along the long electrode.



# Power Supply for Electrode

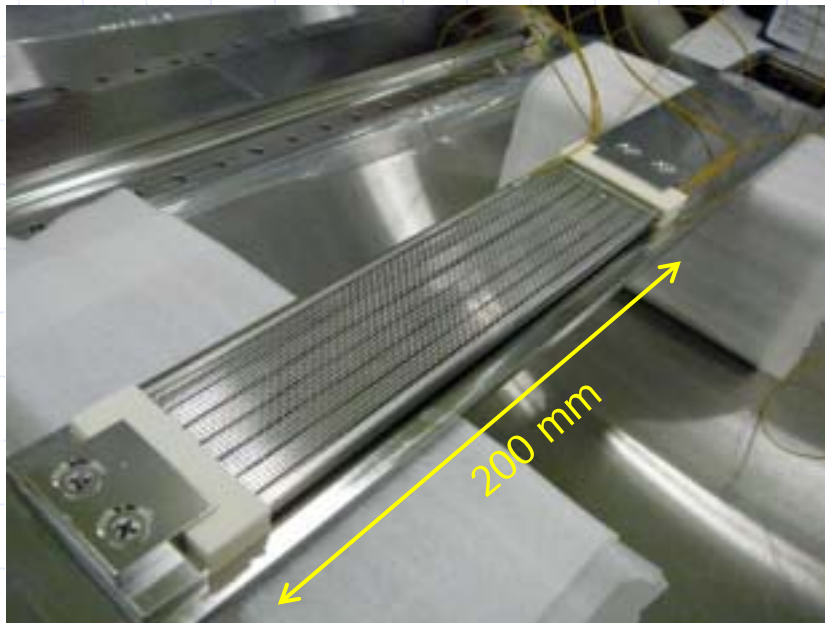
- Power supply



# Electron Monitor

- 7 strip-type collectors measure the horizontal spatial distribution of electrons.

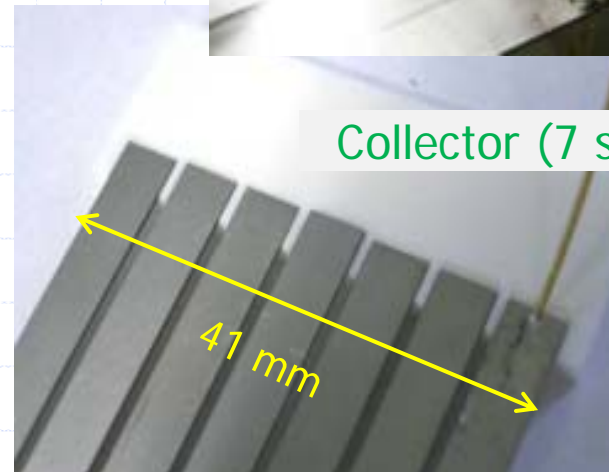
Monitor part



Output feed-through

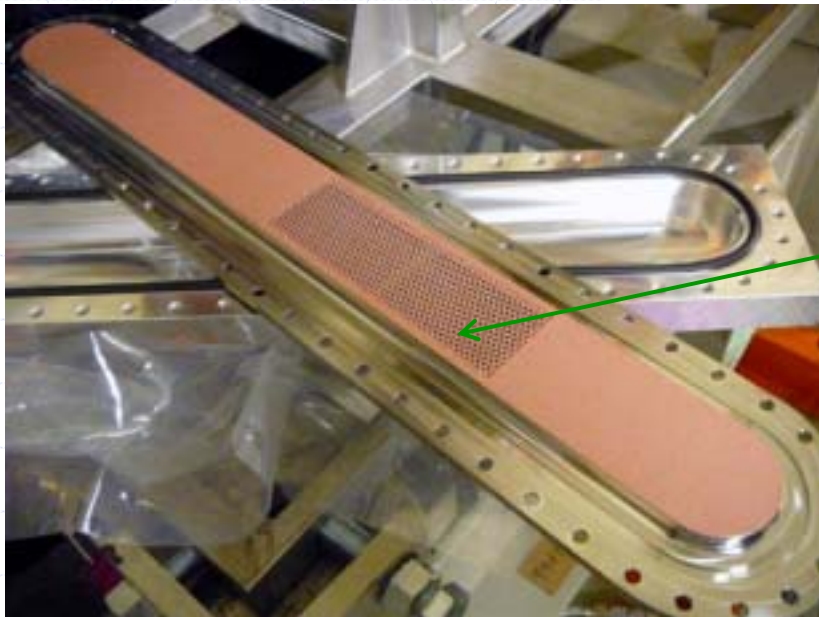
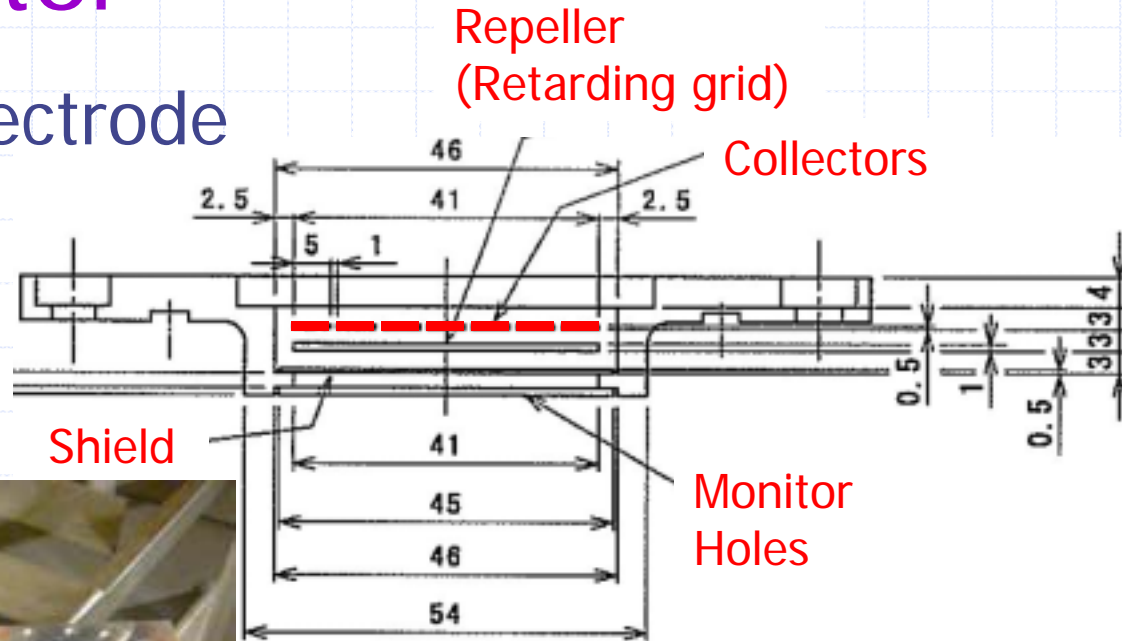


Collector (7 strips)



# Electron Monitor

- Assembly of electrode
  - Four layers
  - With RFA

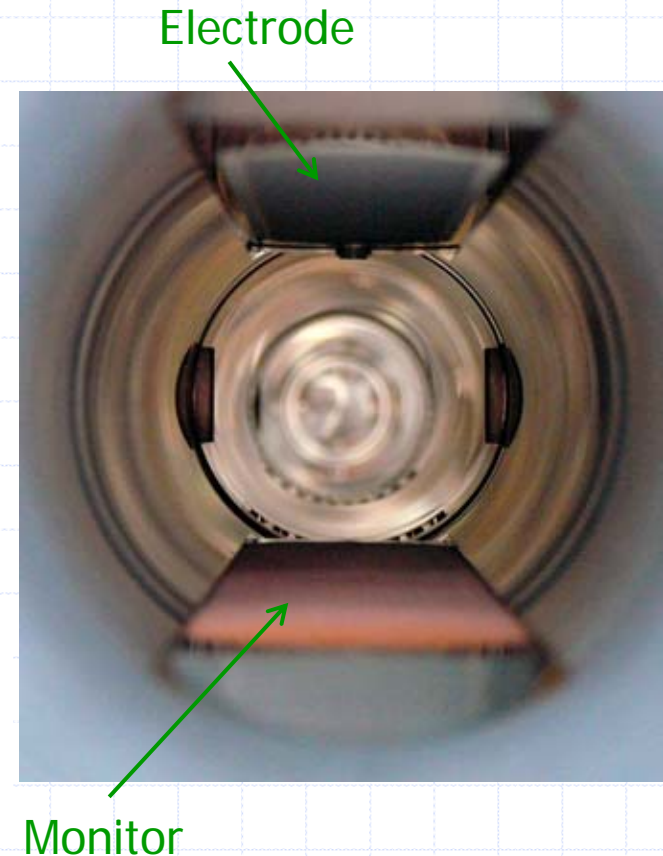
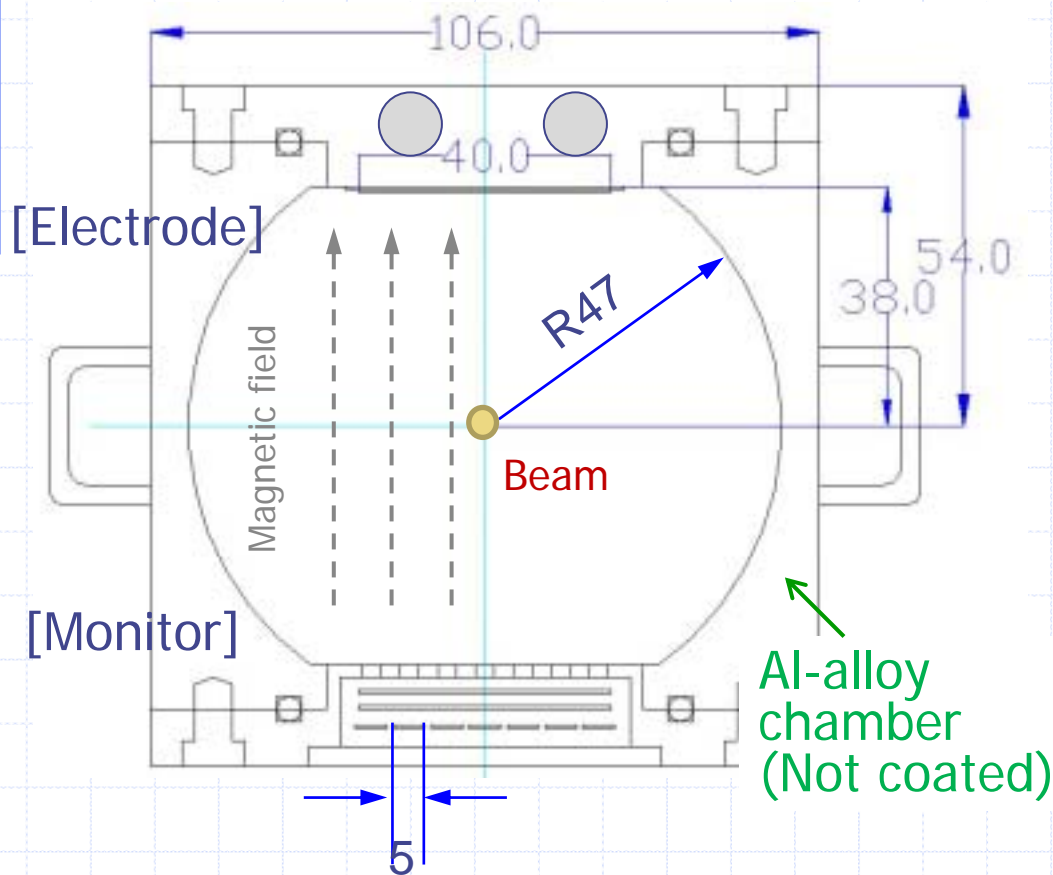


Monitor holes ( $\phi 2$  mm, 3mm pitch)

- Applied voltage
  - Collectors: +100V
  - Retarding Grid: 0 ~ -1 kV
- Measurement: DC mode

# Test chamber

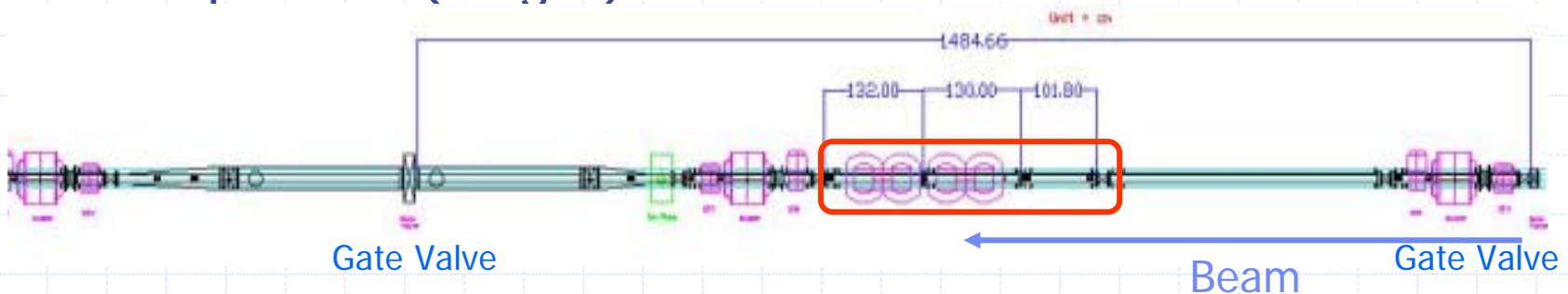
- Electrode and monitor are set face to face
  - Electrode and monitor are detachable.





# Experimental Setup

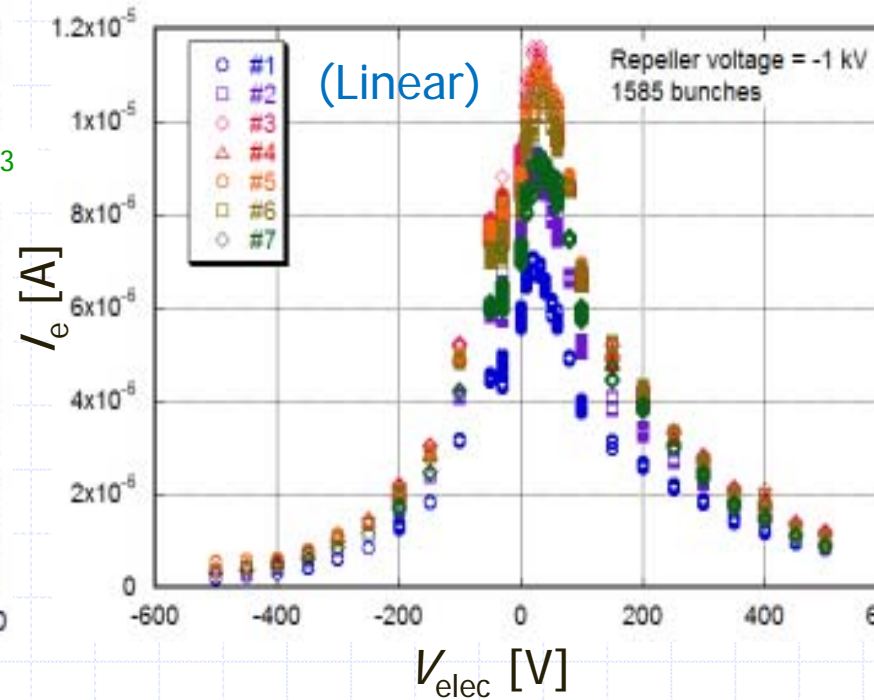
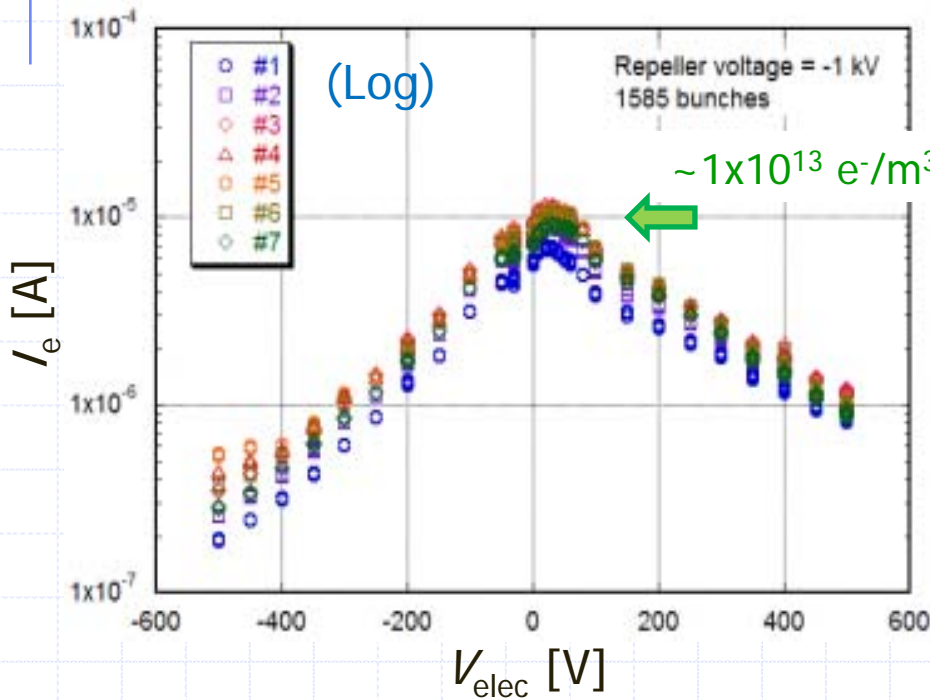
- Test chamber was installed into KEKB Positron ring (Low Energy Ring).
  - 3.5 GeV positron
  - $\sigma_z = 6 \sim 7$  mm
  - Beam current ( $I_b$ )  $\sim 1600$  mA
  - Bunch spacing ( $B_s$ ) 4  $\sim 16$  ns
- Wiggler magnet.
  - Magnetic field: 0.75 T
  - Effective length: 346 mm
  - Aperture (height): 110 mm





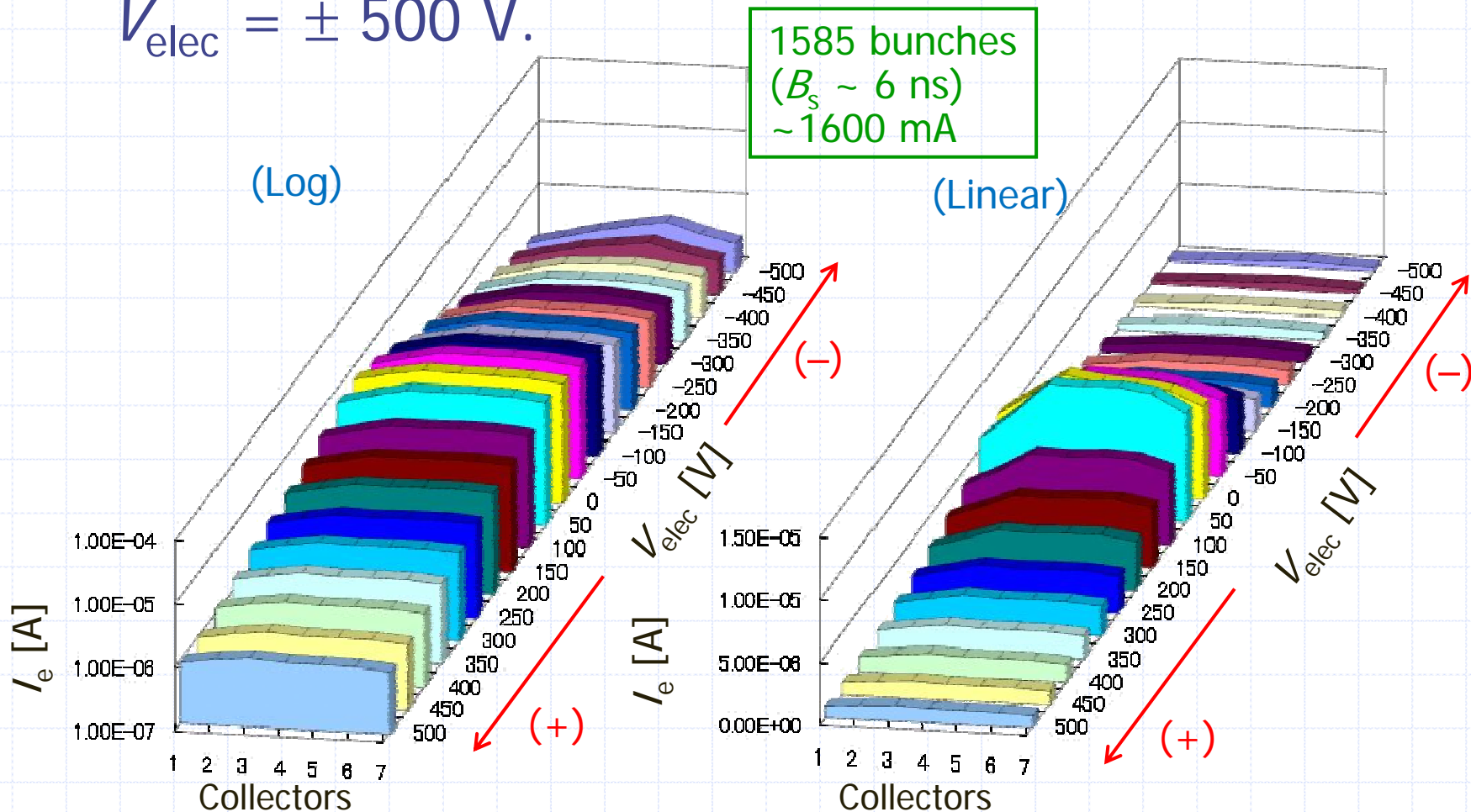
# Results in Field-Free Region

- At first, installed in field-free region
  - 1585 bunches ( $B_s \sim 6$  ns),  $I_b = 1600$ - $1620$  mA
  - $V_r$  (repeller voltage) =  $-1$  kV
  - $V_{\text{elec}}$  (electrode voltage) =  $+500$ V  $\sim$   $-500$ V



# Results in Field-Free Region

- Electron density decreased to  $< 1/10$  at  $V_{\text{elec}} = \pm 500$  V.

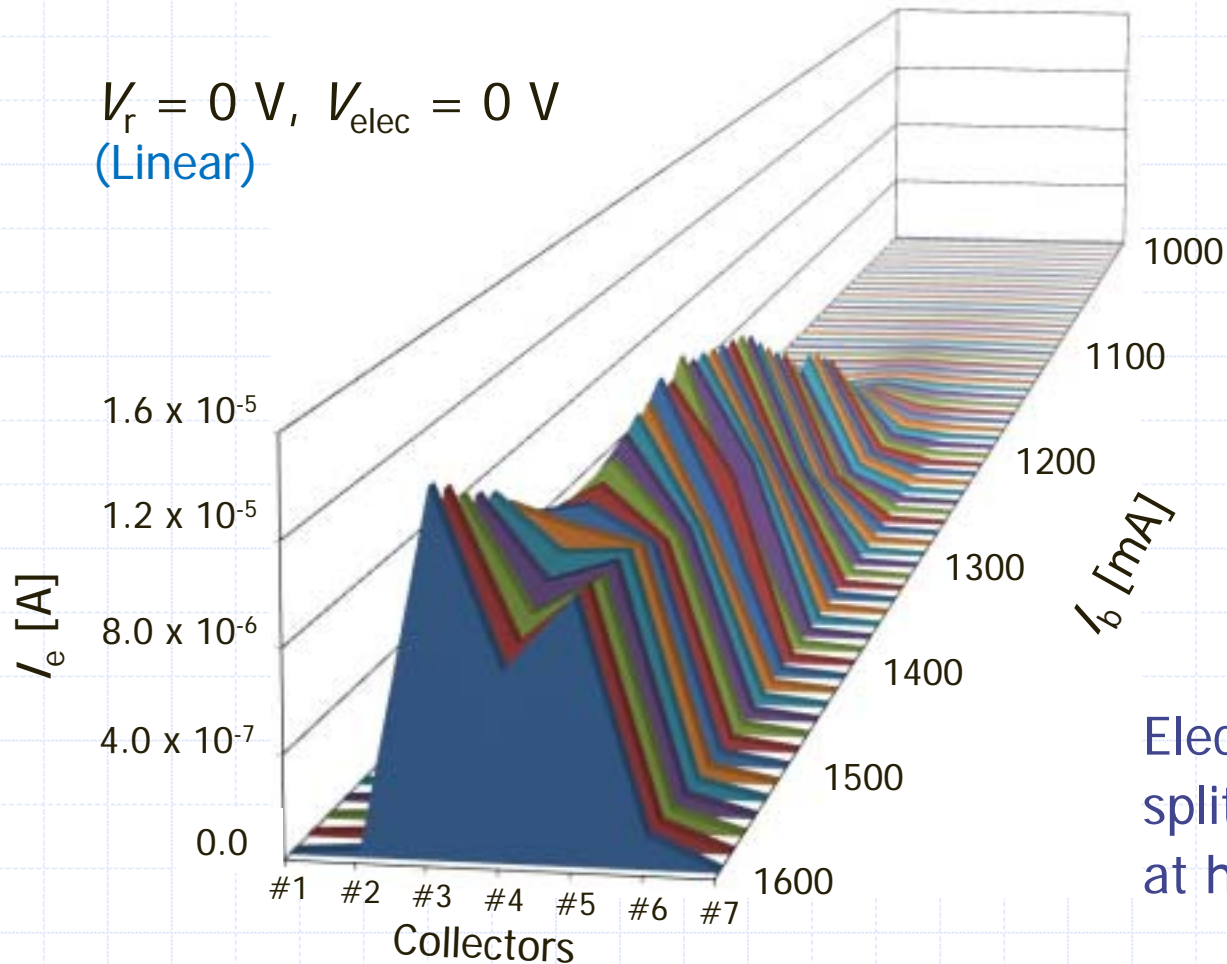


# Results in Magnetic Field

- Spatial distribution during beam injection

$V_r = 0 \text{ V}$ ,  $V_{\text{elec}} = 0 \text{ V}$   
(Linear)

1585 bunches  
( $B_s \sim 6 \text{ ns}$ )

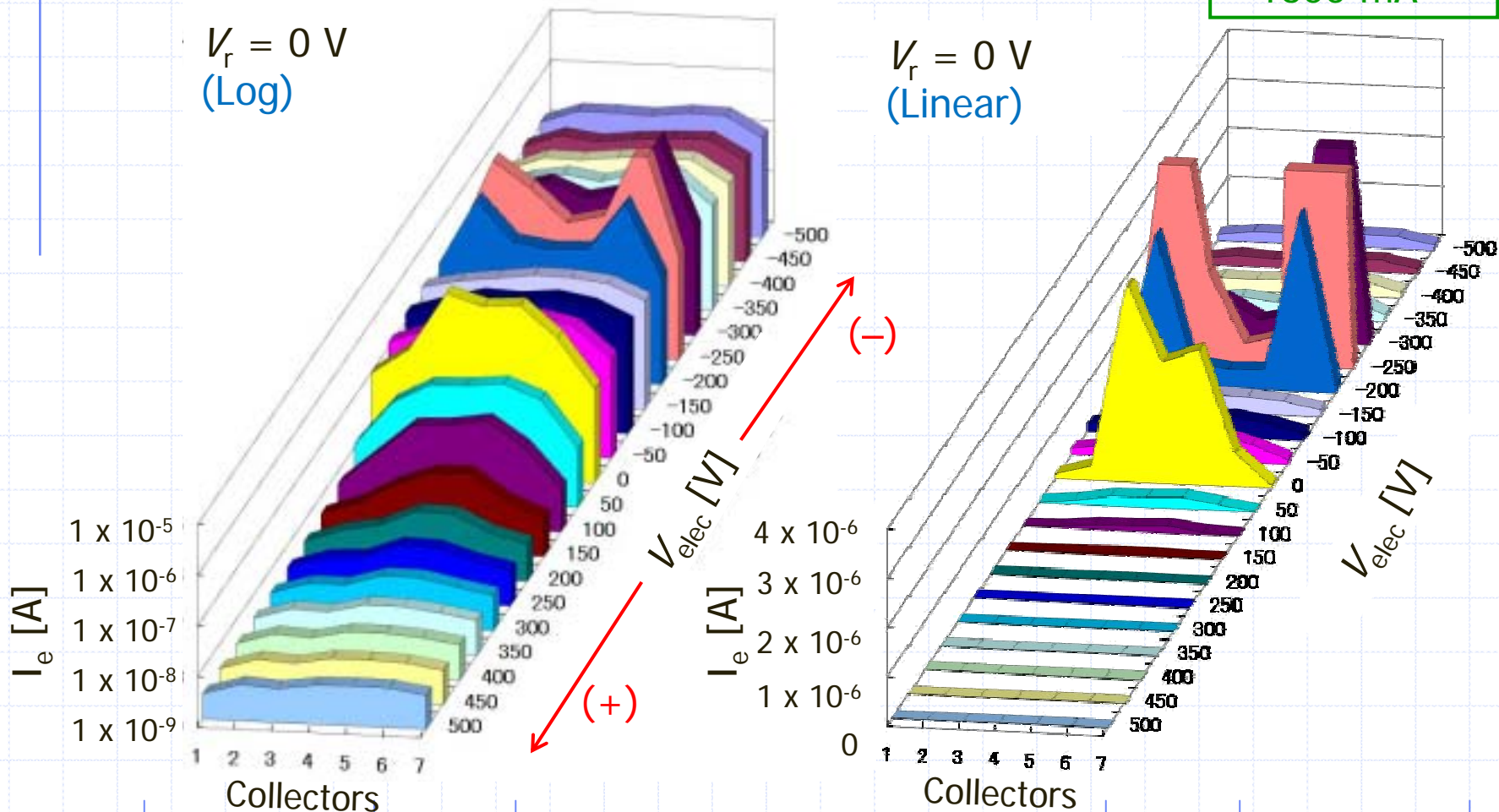


Electron distribution splits to two peaks at high current.

# Results in Magnetic Field

- Effect of electrode voltage ( $V_{elec}$ )

1585 bunches  
( $B_s \sim 6$  ns)  
 $\sim 1600$  mA

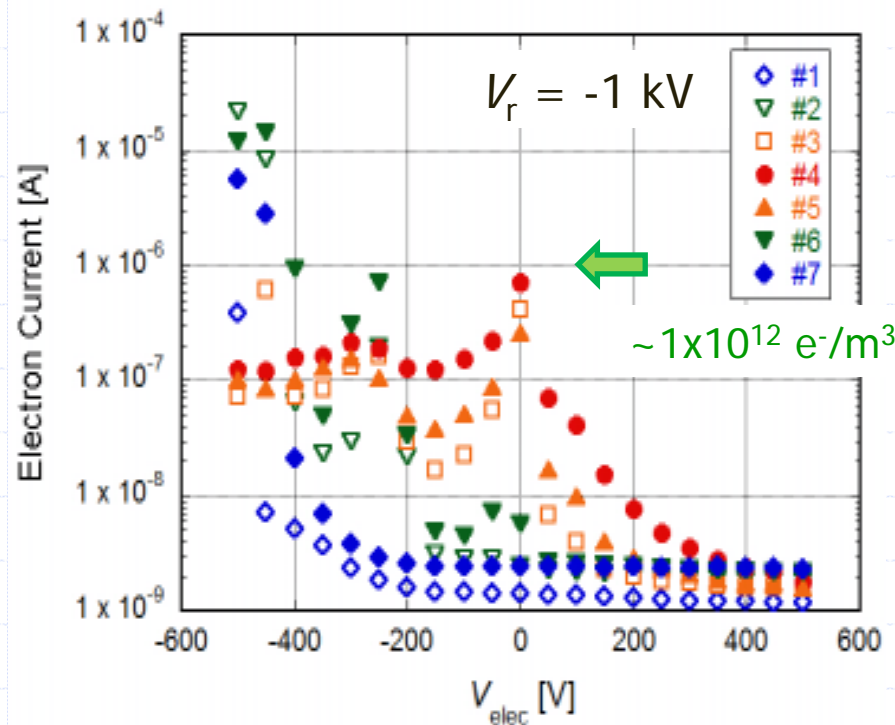
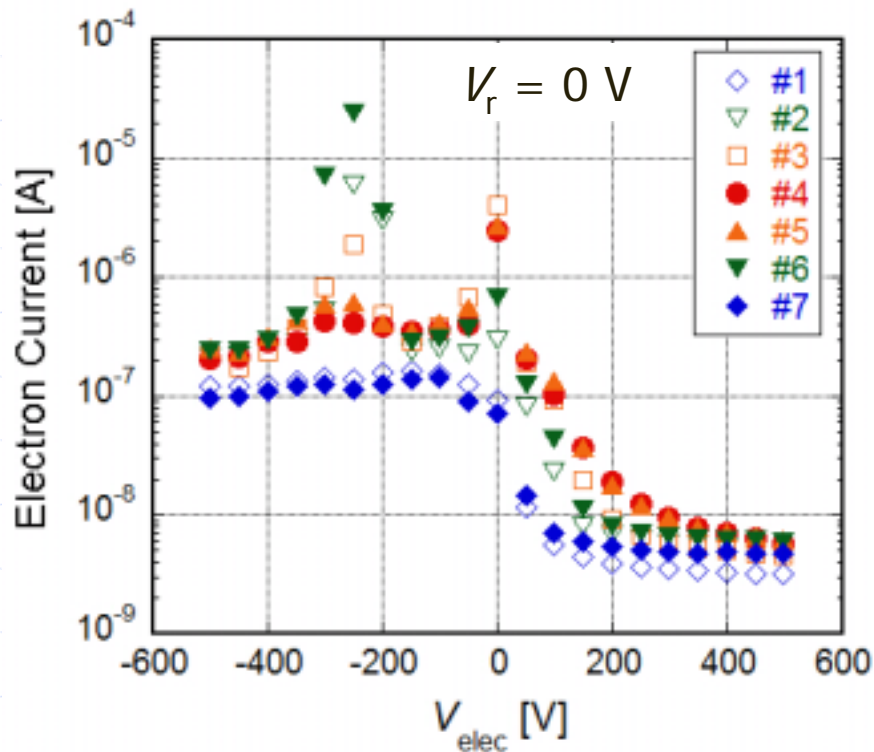




# Results in Magnetic Field

- Effect of electrode voltage ( $V_{\text{elec}}$ )

1585 bunches  
 $(B_s \sim 6 \text{ ns})$   
 $\sim 1600 \text{ mA}$



Complicated behavior at negative  $V_{\text{elec}}$ .

Electron density decreased to  
 $1/10$  at  $V_{\text{elec}} = +100 \sim 200 \text{ V}$   
 $1/100$  at  $V_{\text{elec}} = +300 \sim 400 \text{ V}$

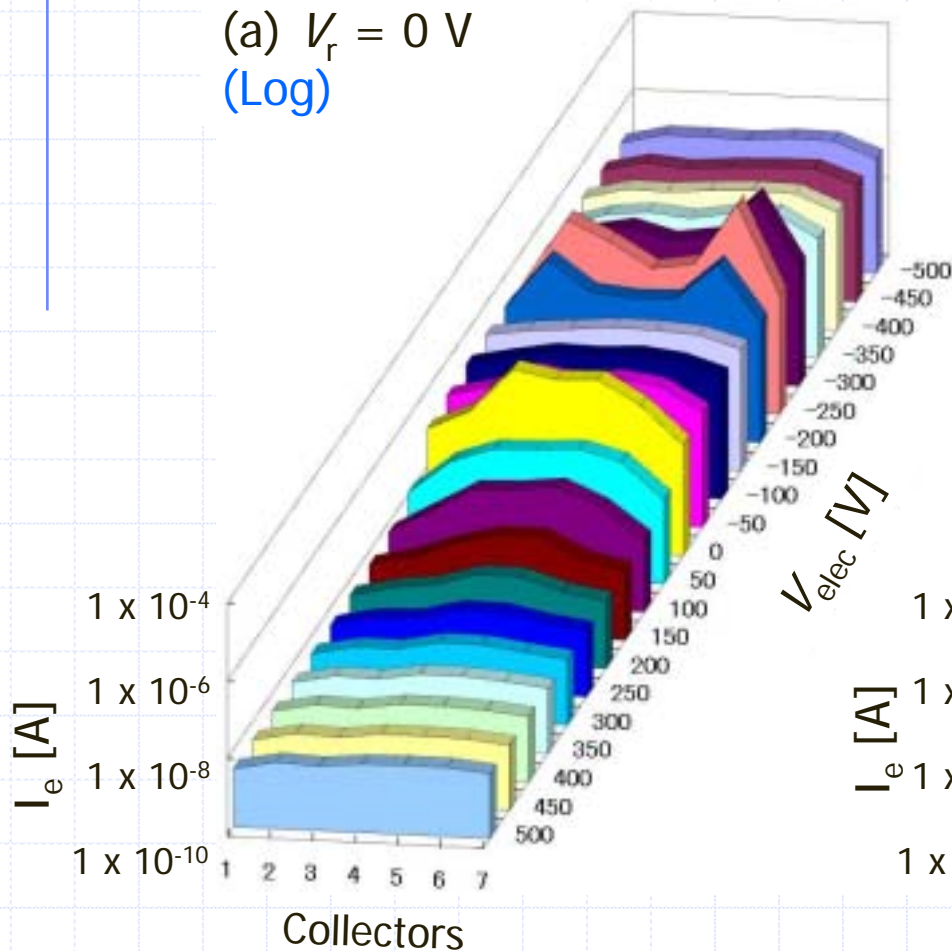


# Results in Magnetic Field

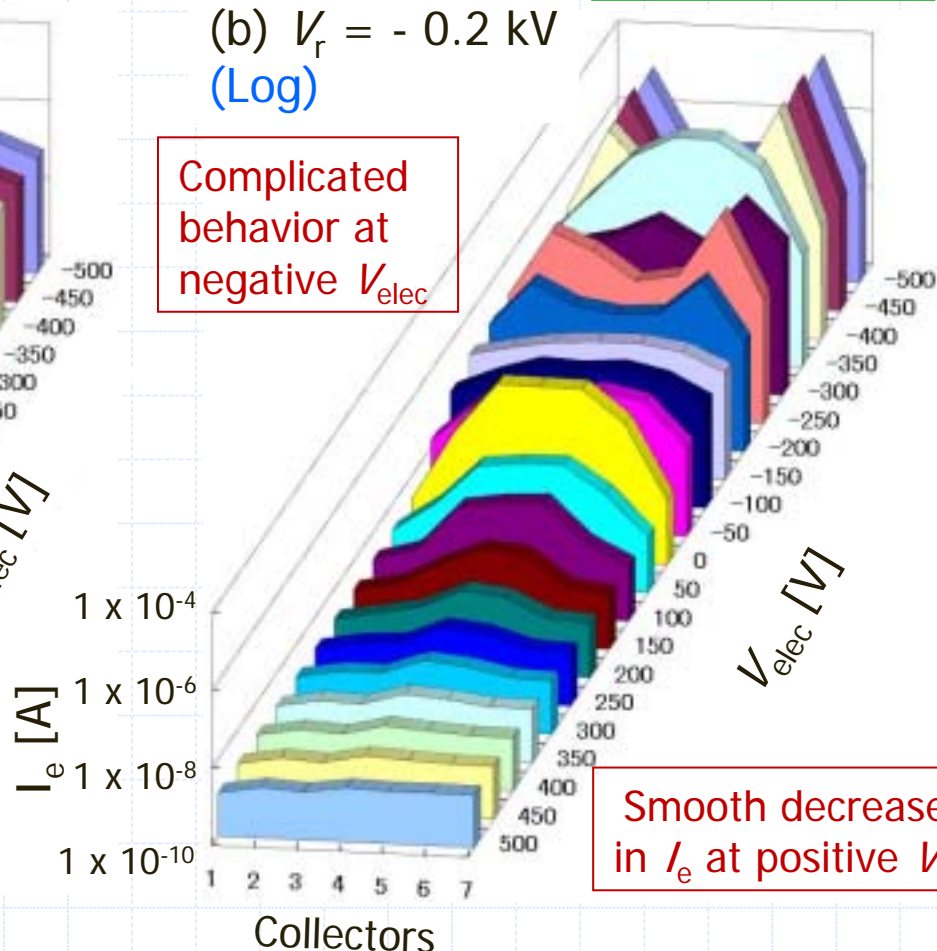
- Effect of repeller voltage ( $V_r$ )

1585 bunches  
( $B_s \sim 6$  ns)  
 $\sim 1600$  mA

(a)  $V_r = 0$  V  
(Log)



(b)  $V_r = -0.2$  kV  
(Log)



Complicated  
behavior at  
negative  $V_{elec}$

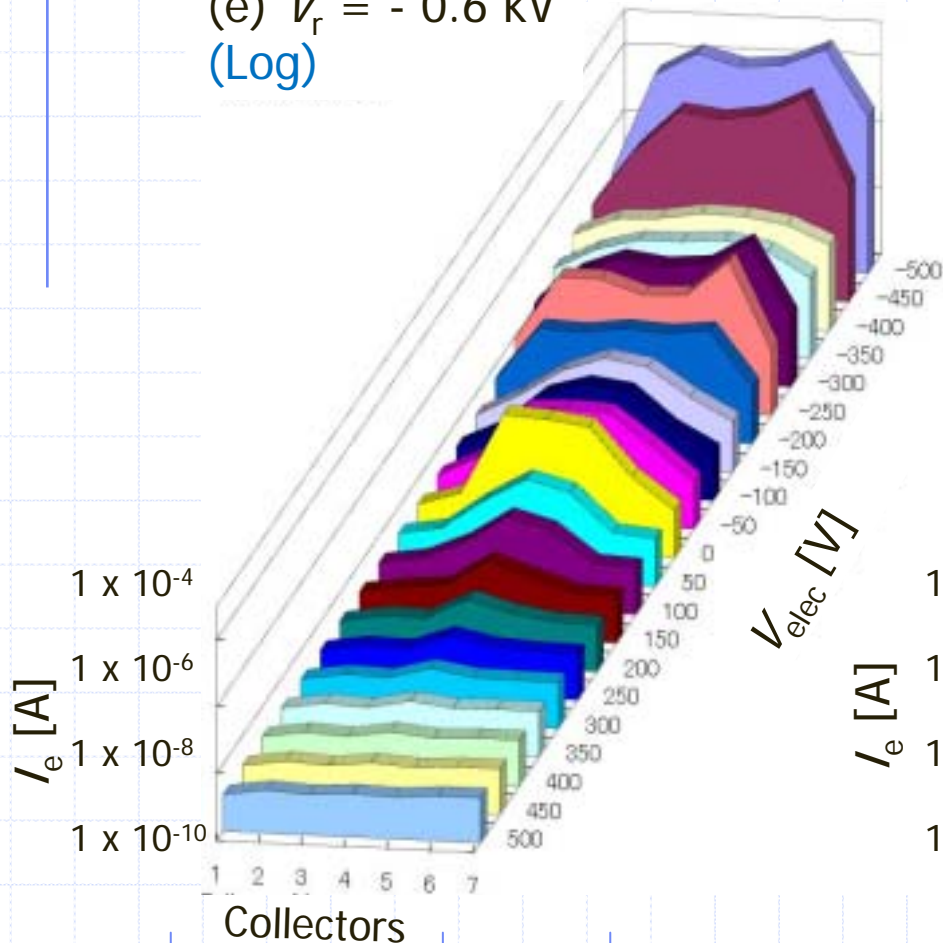
Smooth decrease  
in  $I_e$  at positive  $V_r$

# Results in Magnetic Field

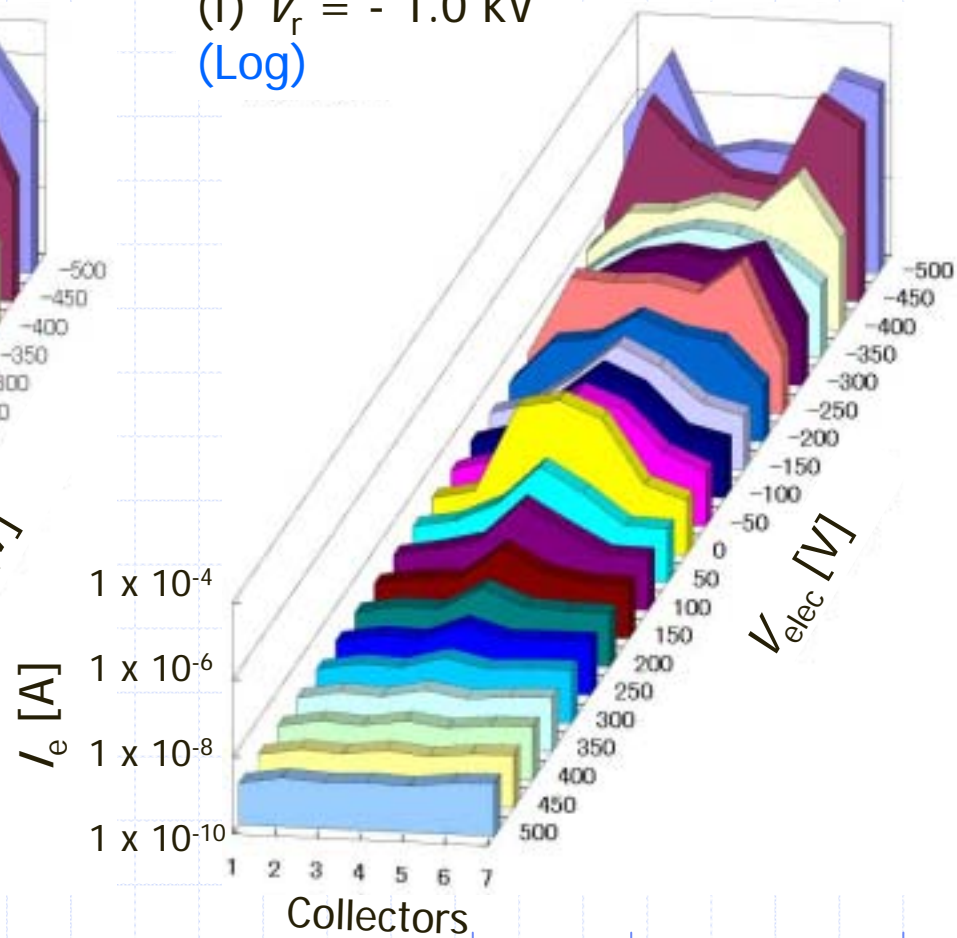
- Effect of repeller voltage ( $V_r$ )

1585 bunches  
( $B_s \sim 6$  ns)  
 $\sim 1600$  mA

(e)  $V_r = -0.6$  kV  
(Log)



(f)  $V_r = -1.0$  kV  
(Log)

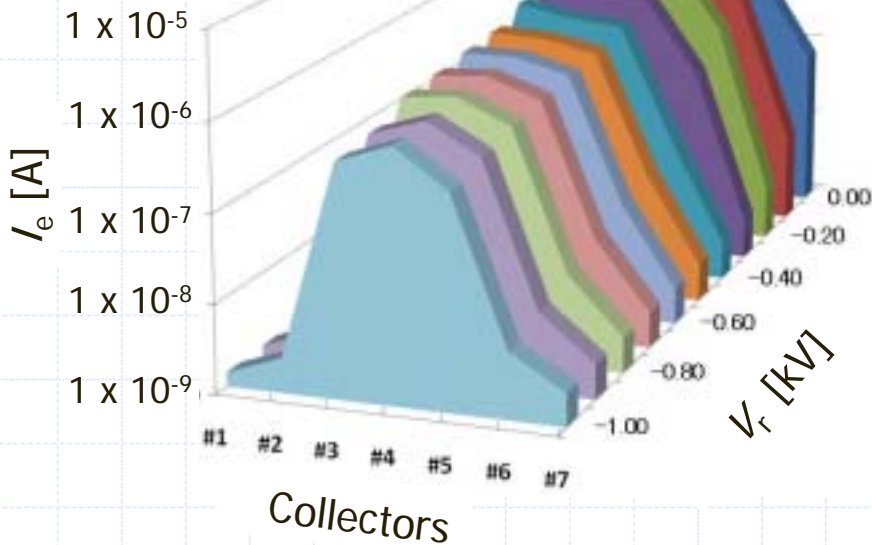


# Results in Magnetic Field

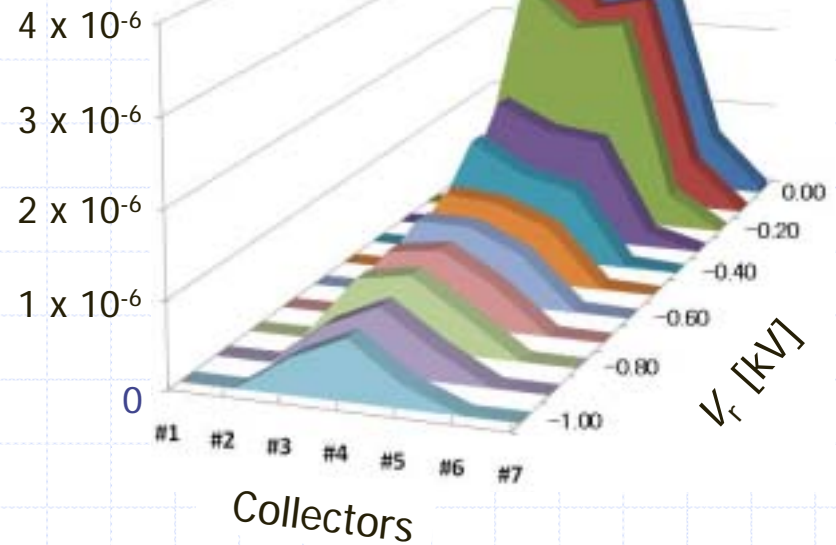
- Energy Distribution
  - High energy electrons are around the center (beam orbit)

1585 bunches  
( $B_s \sim 6$  ns)  
 $\sim 1600$  mA

$V_{\text{elec}} = 0$  V  
(Log)



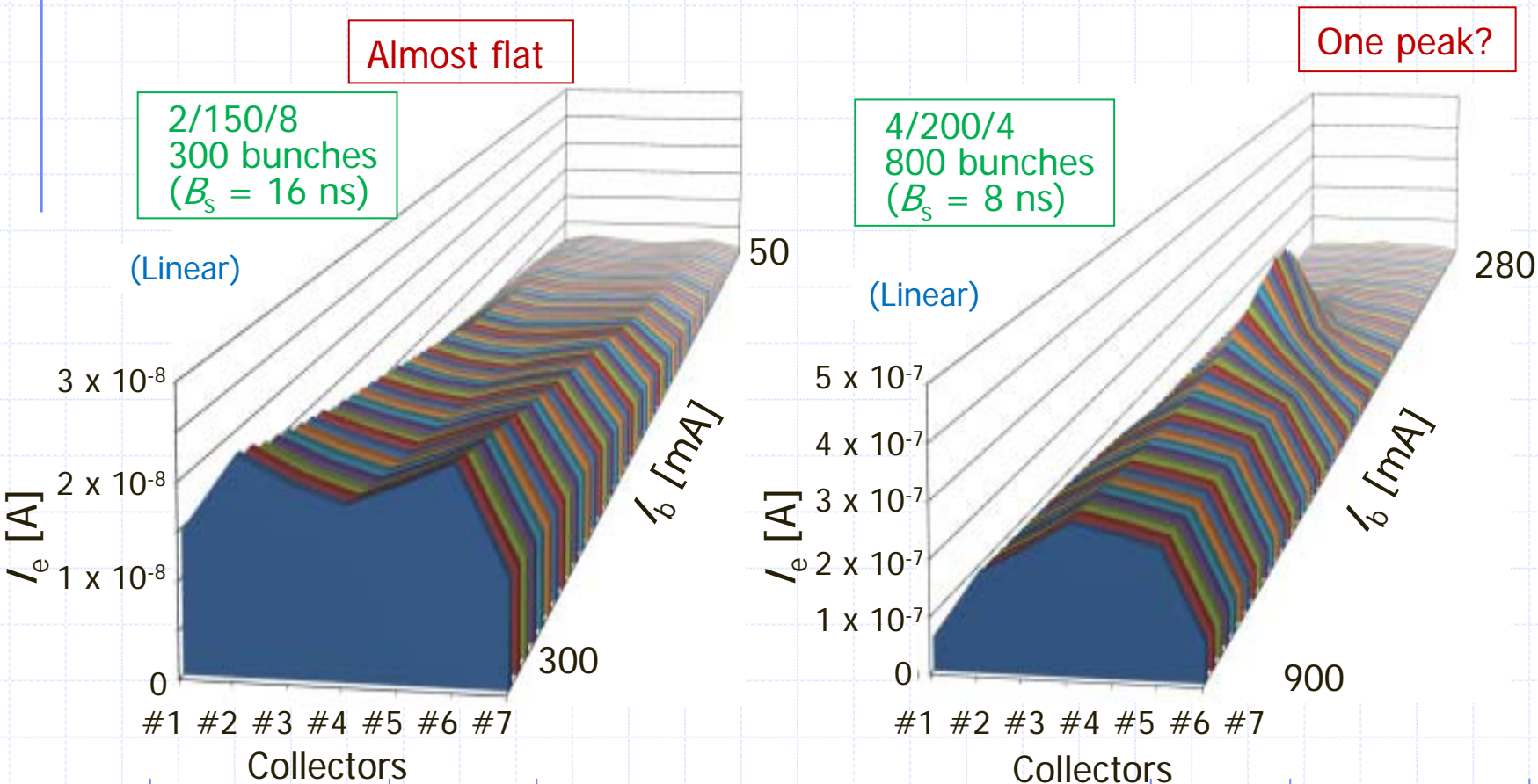
$V_{\text{elec}} = 0$  V  
(Linear)





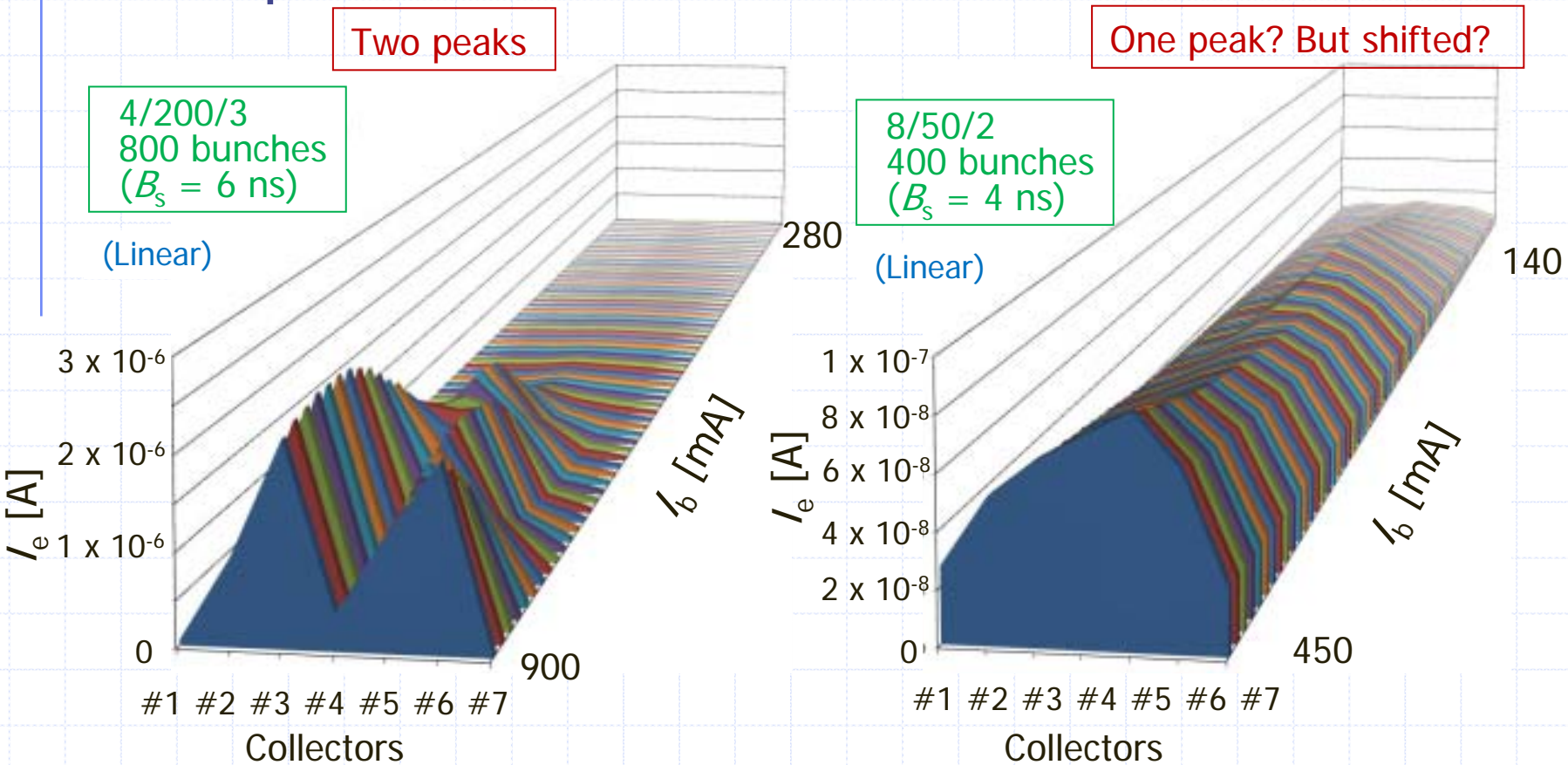
# Results in Magnetic Field

- Fill patterns
  - Spatial distribution changes by bunch filling pattern.



# Results in Magnetic Field

- Fill patterns



Why? Poor resolution of electron monitor?

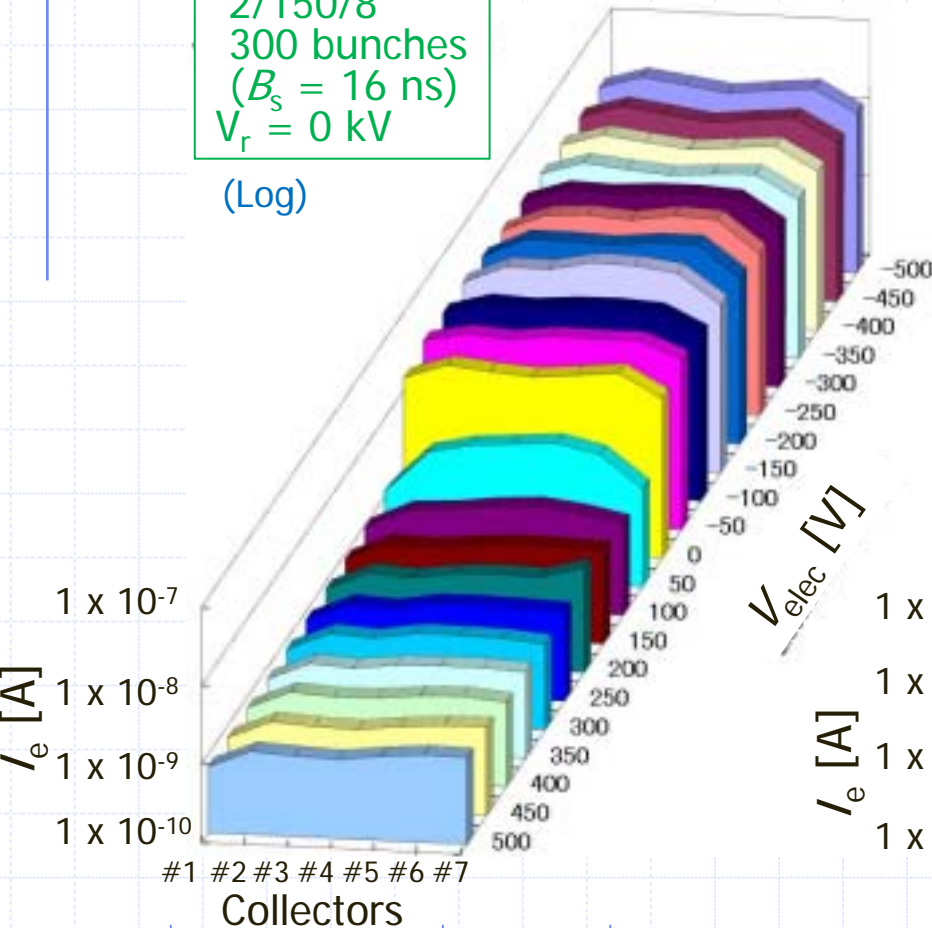


# Results in Magnetic Field

- Fill patterns

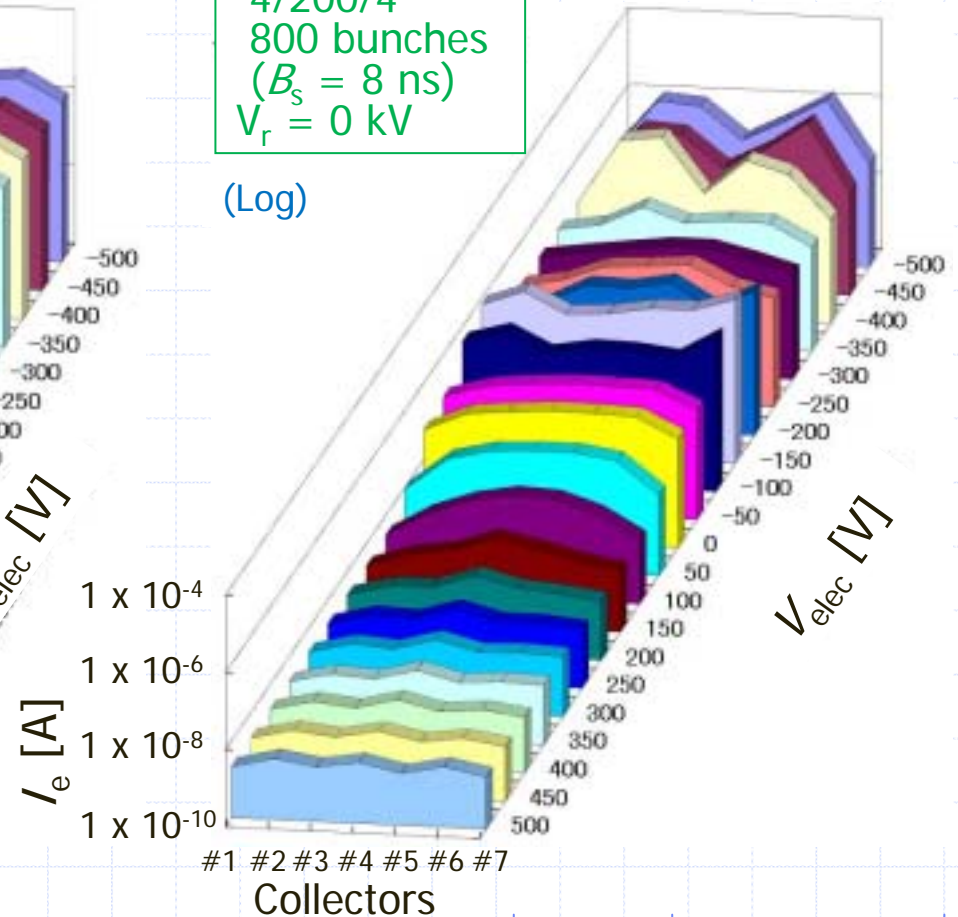
2/150/8  
300 bunches  
( $B_s = 16$  ns)  
 $V_r = 0$  kV

(Log)



4/200/4  
800 bunches  
( $B_s = 8$  ns)  
 $V_r = 0$  kV

(Log)

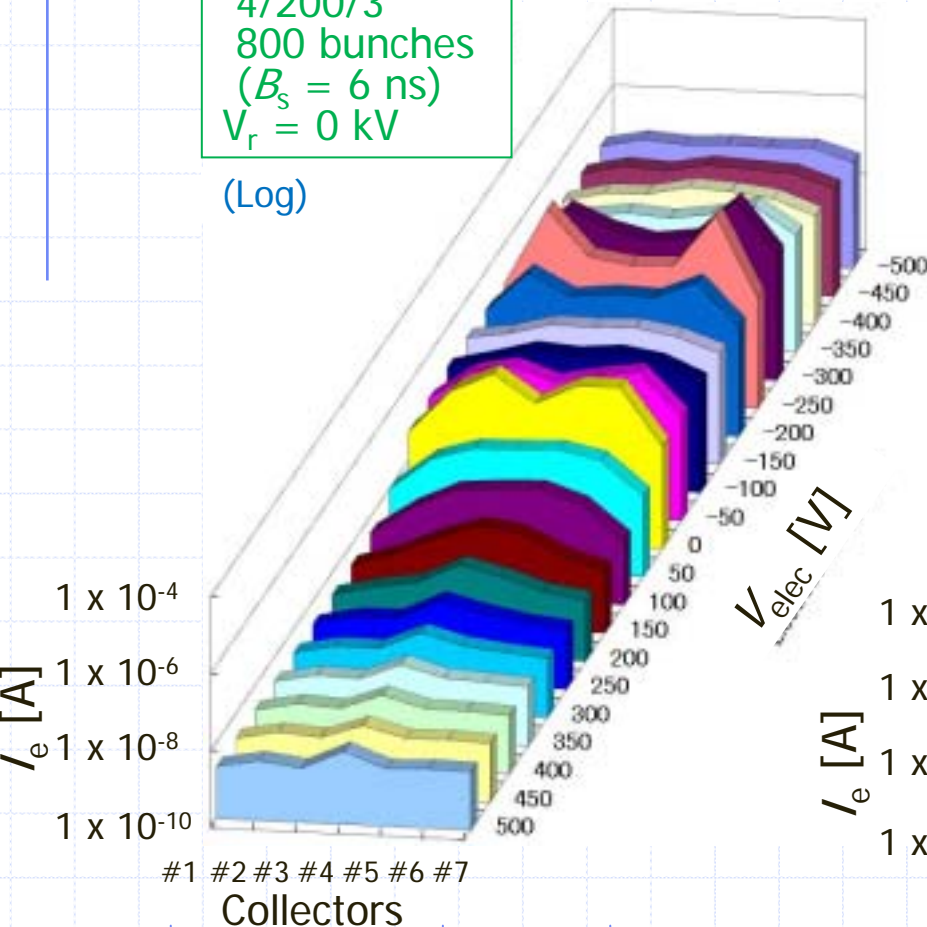


# Results in Magnetic Field

- Fill patterns

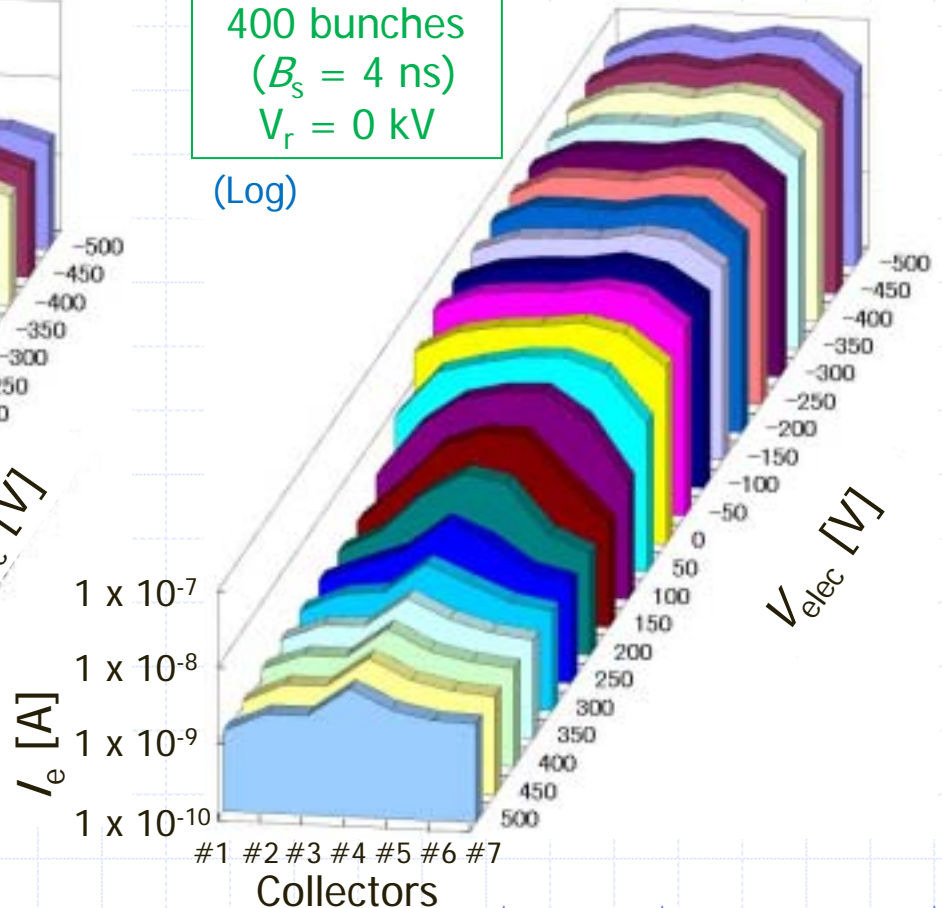
4/200/3  
800 bunches  
( $B_s = 6$  ns)  
 $V_r = 0$  kV

(Log)



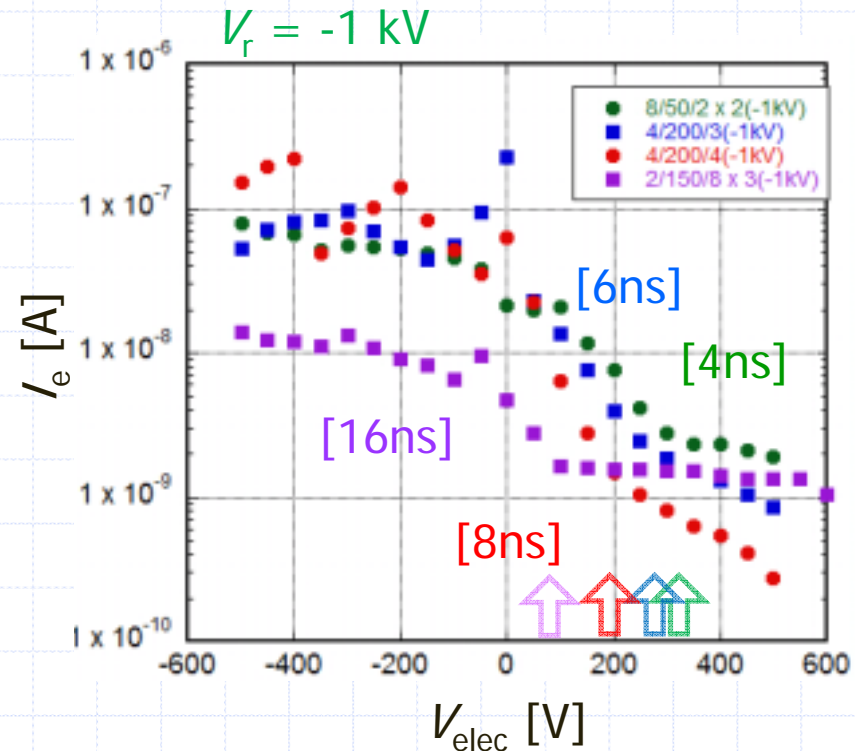
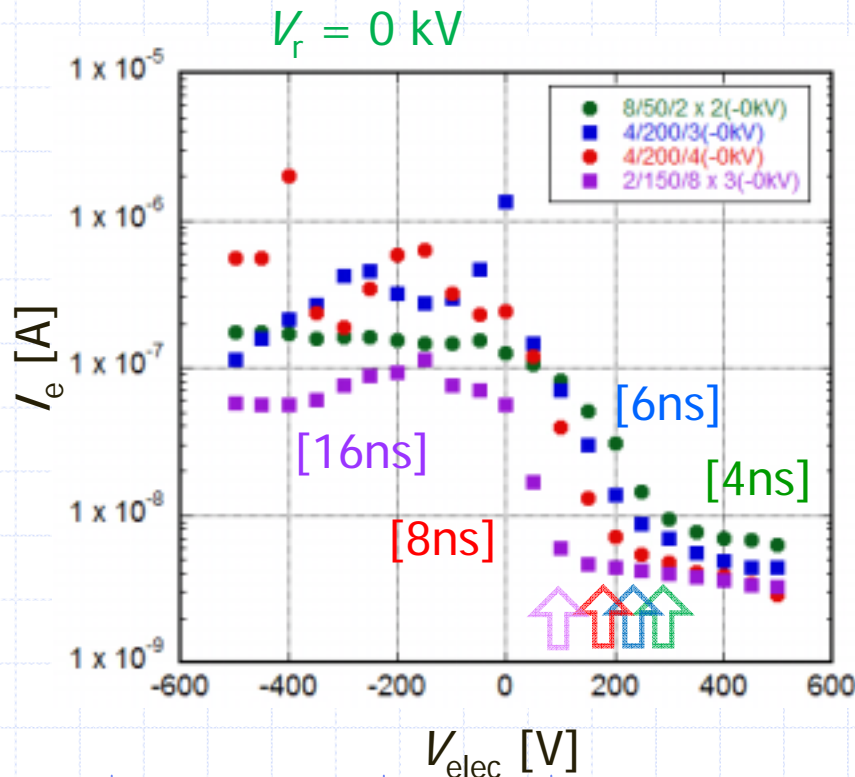
8/50/2  
400 bunches  
( $B_s = 4$  ns)  
 $V_r = 0$  kV

(Log)



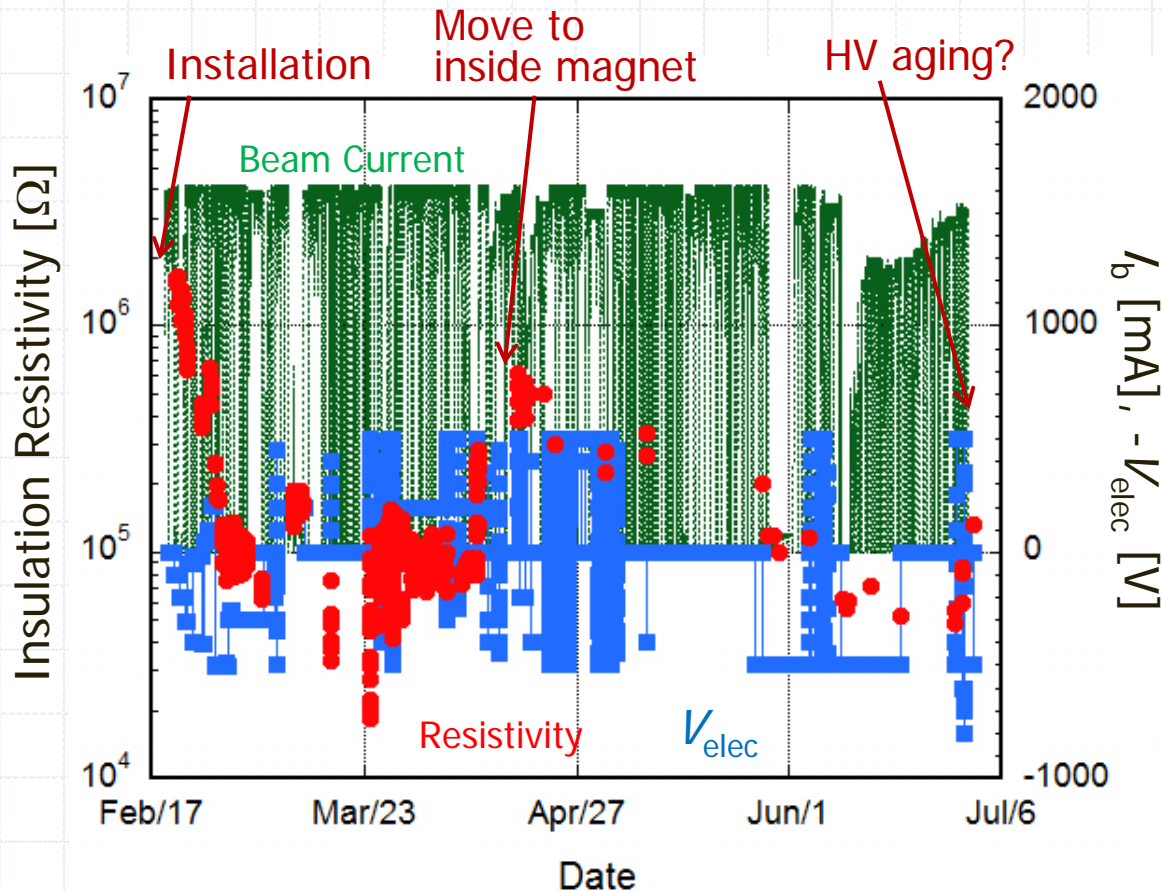
# Results in Magnetic Field

- Fill patterns
  - Electrode is effective for any fill patterns.
  - The efficiency seems different by bunch spacings.
    - Less effective for larger Bs?



# Problems

- Decrease in insulation resistivity
  - Decreased from 2 M $\Omega$  down to several 10 k $\Omega$



- Not strong dependence on  $V_{elec}$
- HV aging (discharge) seemed to recover the resistivity.

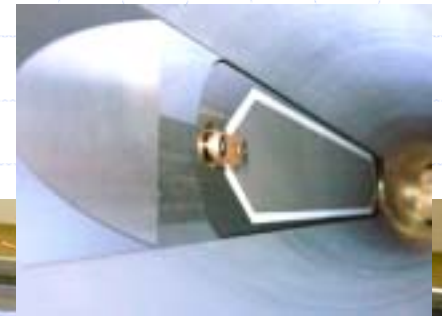
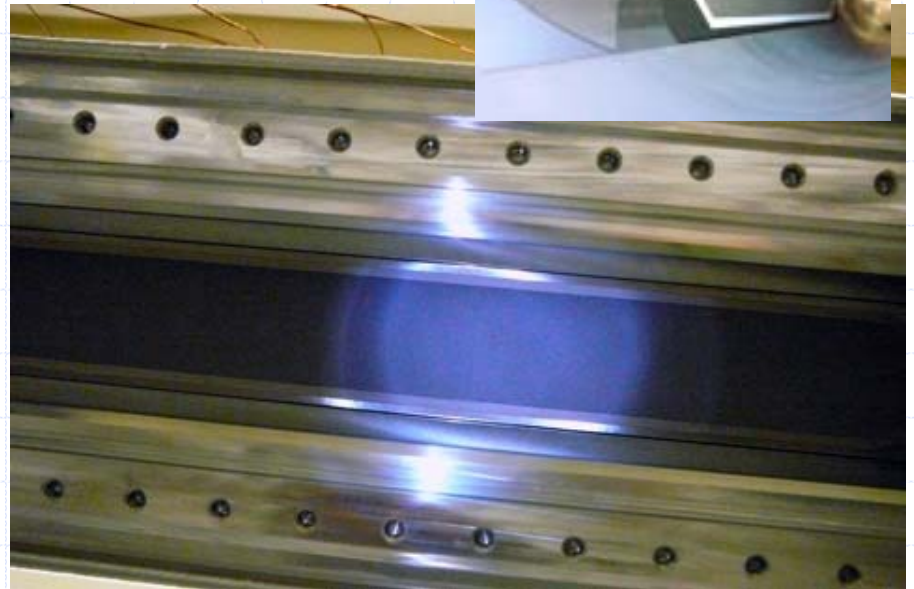
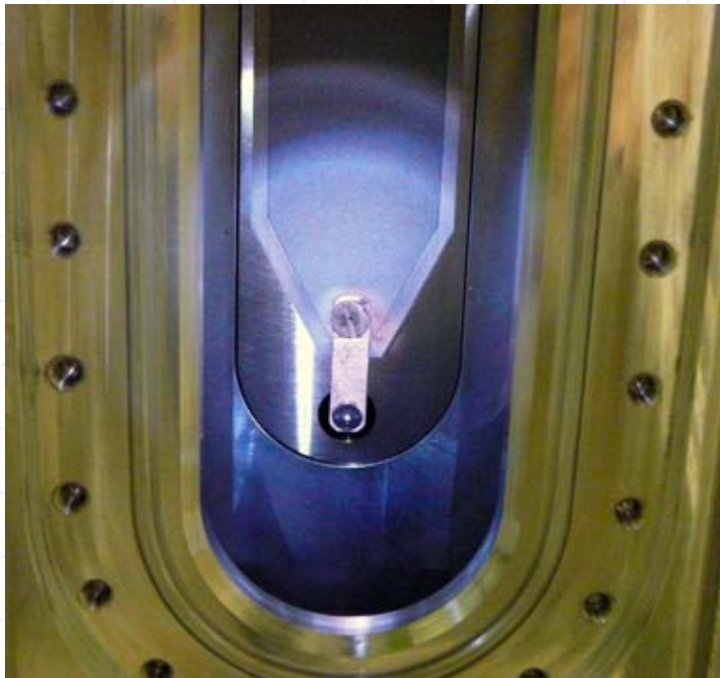


# Problems

- Possible reasons of the decrease in resistivity
  - Sputtering of aluminum (chamber)?
  - Discharge at connection part?

Inside check when moved into inside magnet

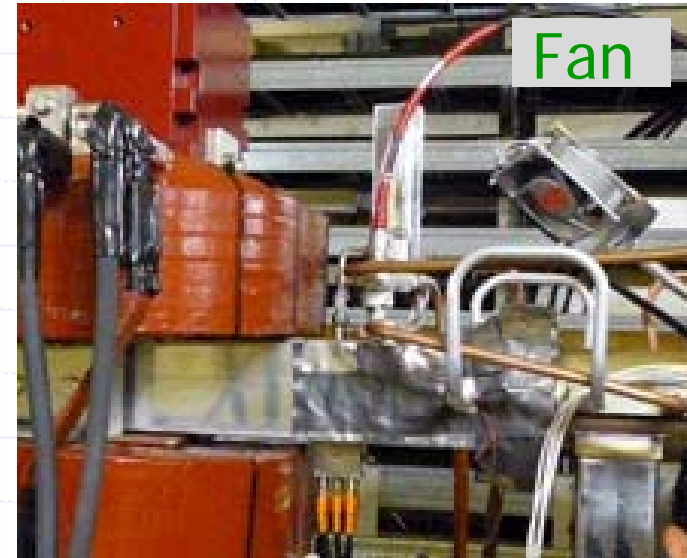
Original color





# Problems

- Heating of feed-through
  - Cooled by air and water
  - Mismatching of impedance?
- Vacuum leak at flange
  - Insufficient fastening?



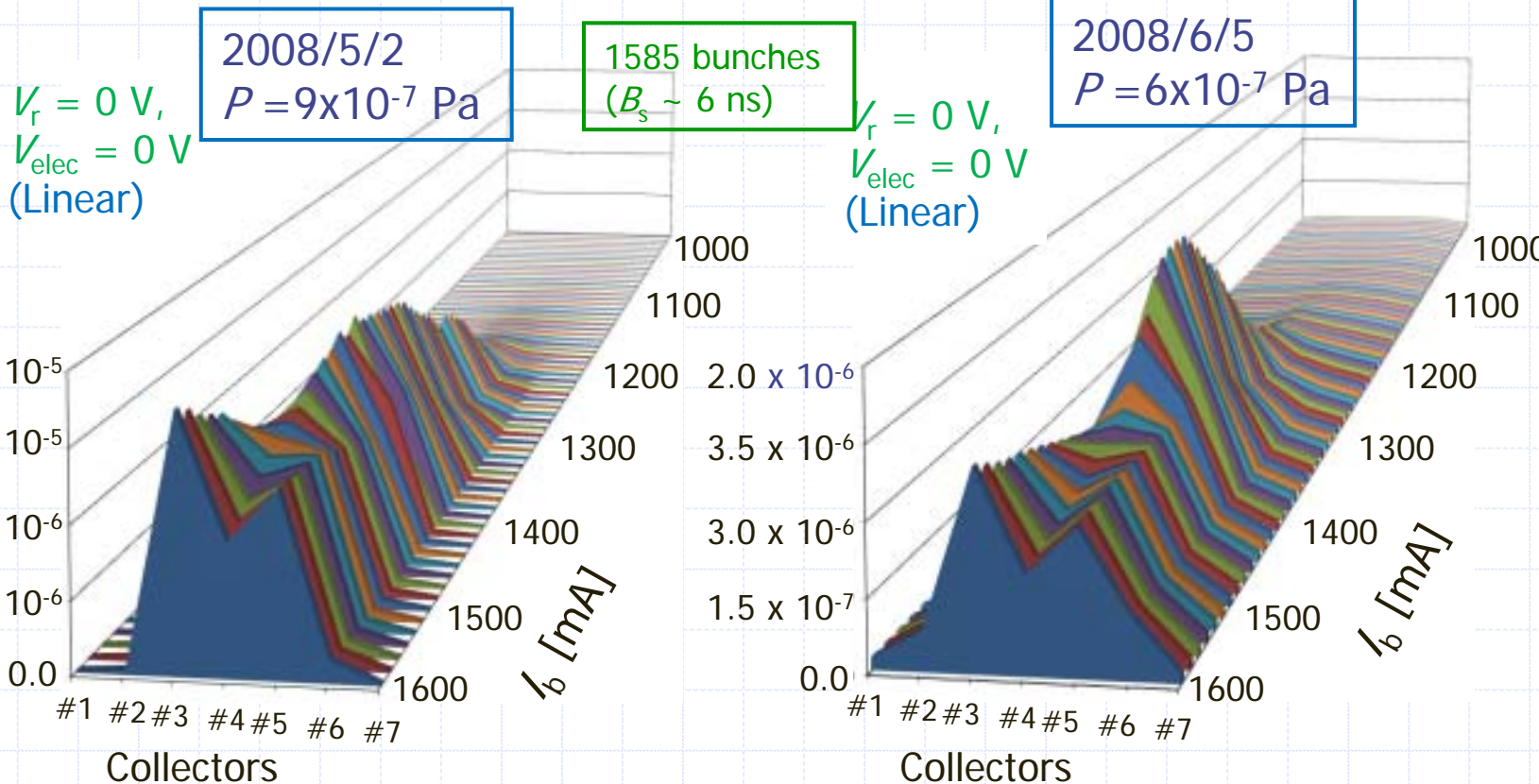
- No problem for
  - Temperature of electrode (test chamber)
  - Power supply

# Mysteries at present

- Complicated behavior of  $I_e$  at negative  $V_{elec}$ , especially for high  $|V_r|$ .
  - Not seen in field-free region → effect of magnetic field
  - Electrons can move only along magnetic field lines.
  - Effect of monitor (holes, repeller grid)?
- Saturation of  $I_e$  at high positive  $V_{elec}$ .
  - Background of monitor (SR?) ?
  - But sometimes  $I_e$  goes down further?
- Spatial distributions for different bunch fill patterns
  - Simulation indicated two peaks for all patterns.
  - Poor resolution of monitor?

# Mysteries at present

- Changes in time
  - Aging of surface?
  - Vacuum pressure (ionization)?



# Summary

- A clearing electrode structure with thin electrode and insulator was developed.
  - The thin structure reduced the beam impedance and enhance the thermal conductivity, which make the electrode available in a high-intensity positron machine.
- Clear effect of clearing electrode on the reduction of EC was experimentally demonstrated, both in field-free region and in magnet (0.75 T).
- Some mysteries, such as decrease in resistivity, complicated behavior of measured electron current at negative electrode voltage, remains at present.
  - Further investigation and simulation to understand the mysteries are required.
- Improvement of the electrode structure, to avoid discharges, and the electron monitor is planned.
- How to apply it to real machines ..... to be considered.

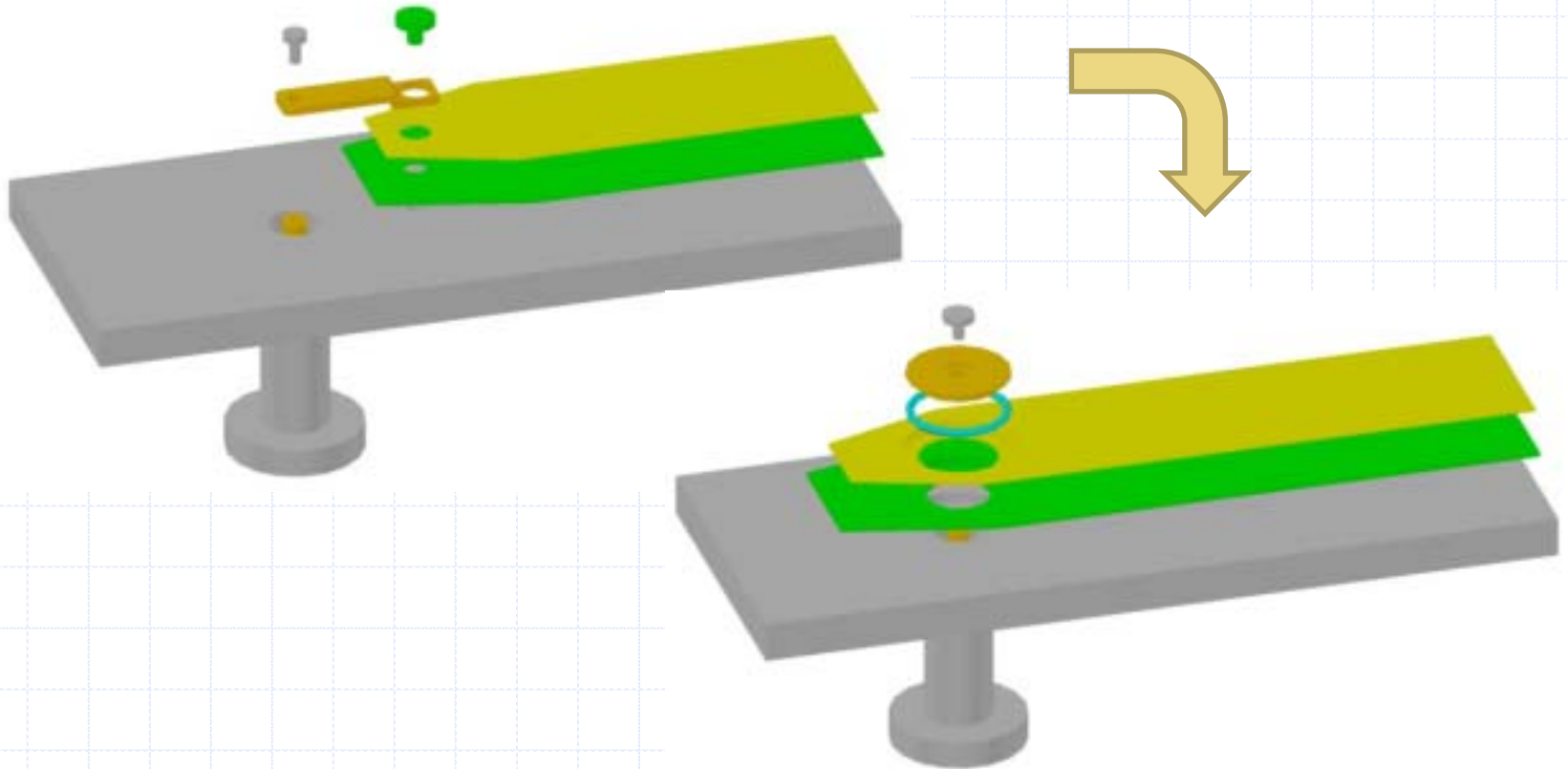


# Backup



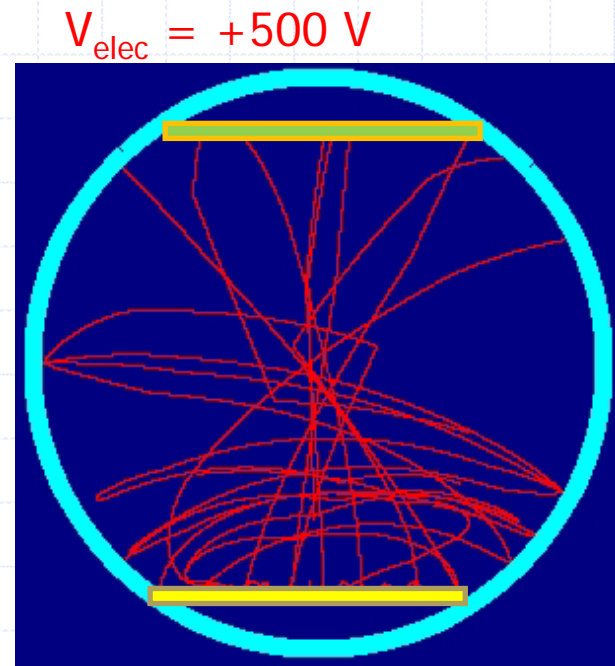
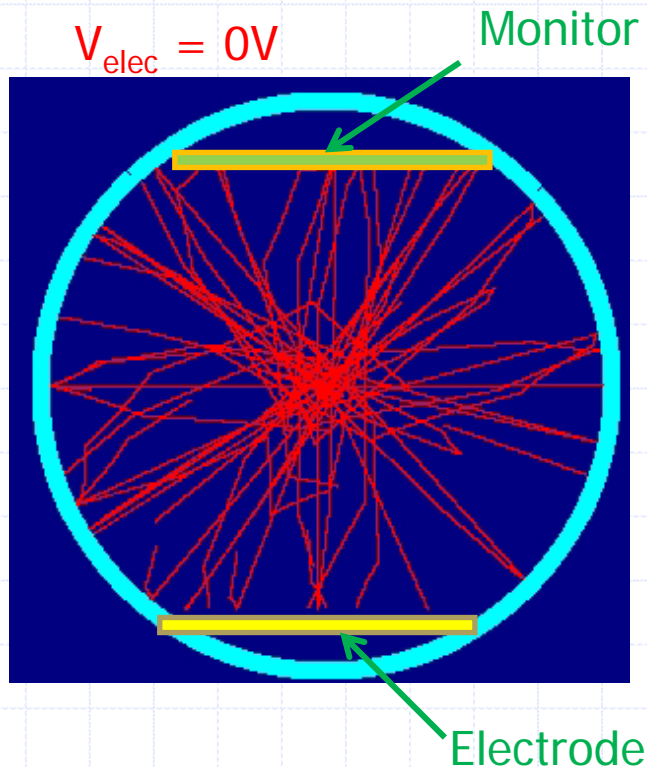
# Next version

- Improvement of connector
  - Suggested by Billing-san



# Simulation [Preliminary]

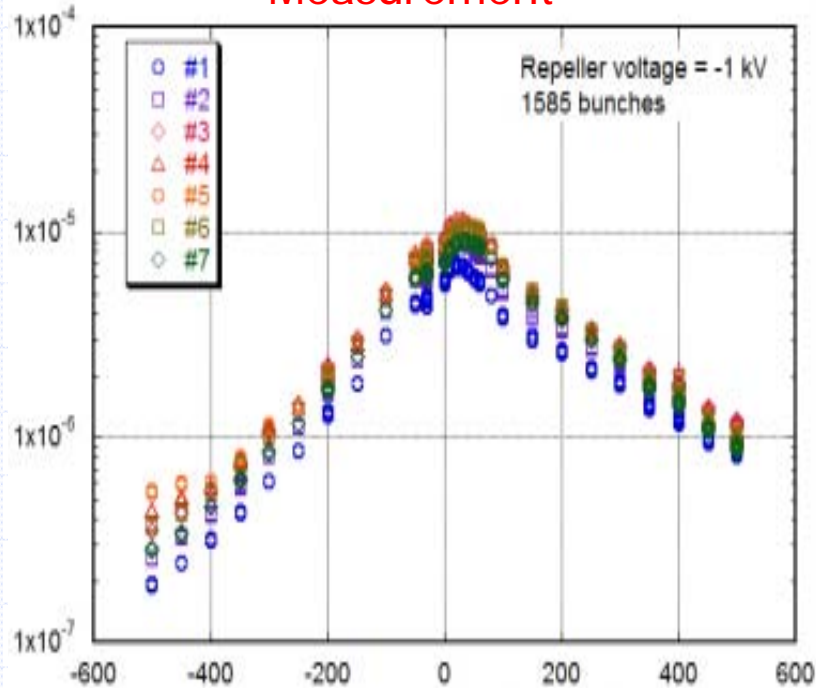
- Trajectories of electrons
  - Field-Free Region
  - $1/1585/3$  ( $B_s \sim 6$  ns)



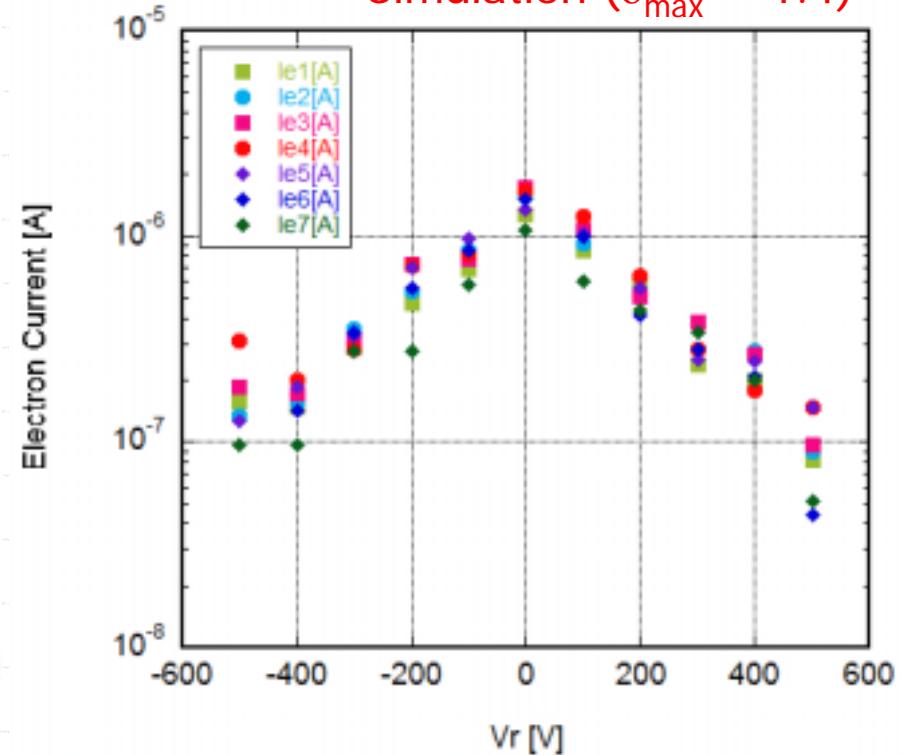
# Simulation [Preliminary]

- Measured Electron Current ( $I_e$ )
  - Field-Free Region
  - 1/1585/3 ( $B_s \sim 6$  ns),  $V_r = -1$  kV

Measurement



Simulation ( $\delta_{\max} = 1.4$ )

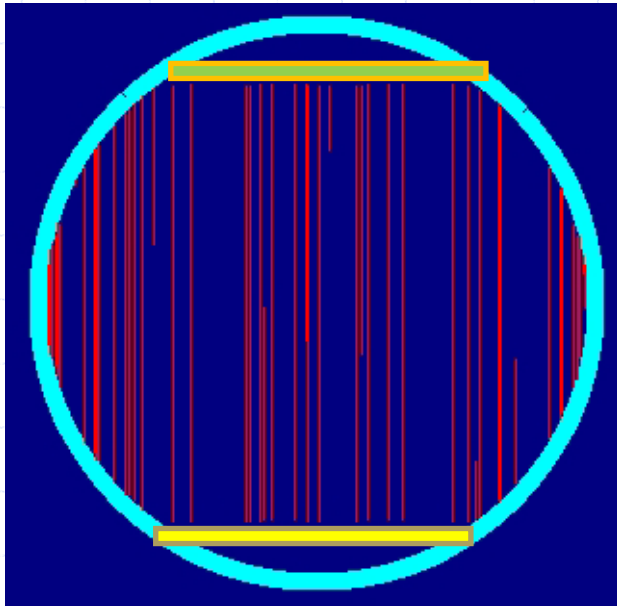




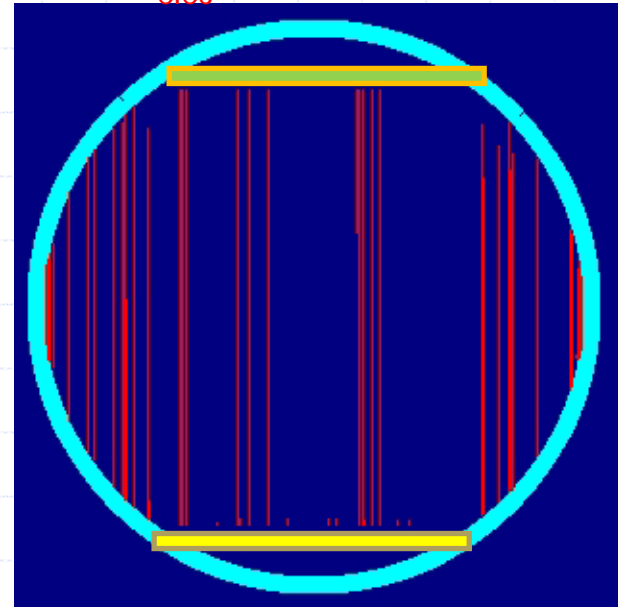
# Simulation [Preliminary]

- Trajectory of electrons
  - In magnetic field, but cyclotron motion was neglected for simplicity.
  - $1/1585/3$  ( $B_s \sim 6$  ns)

$V_{\text{elec}} = 0\text{V}$



$V_{\text{elec}} = +500\text{V}$

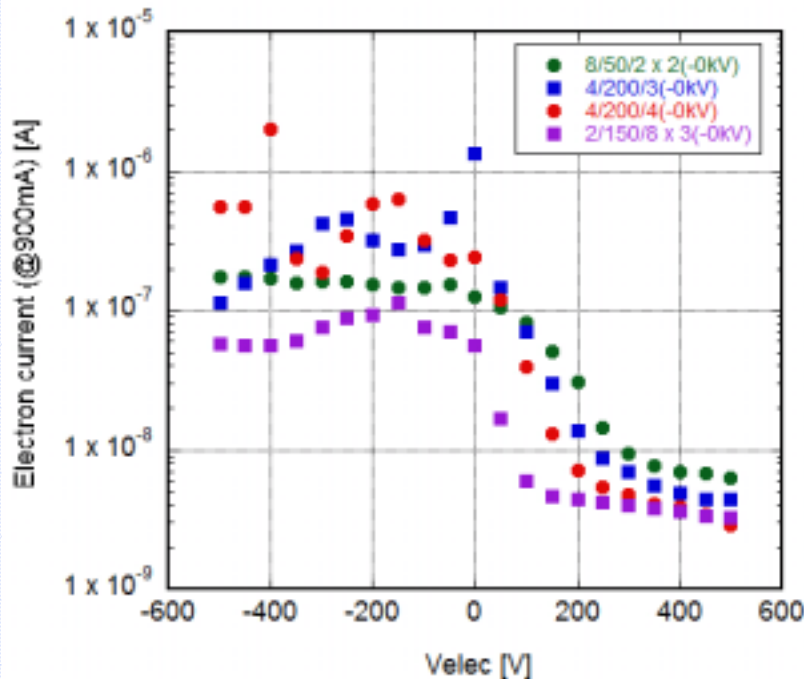


# Simulation [Preliminary]

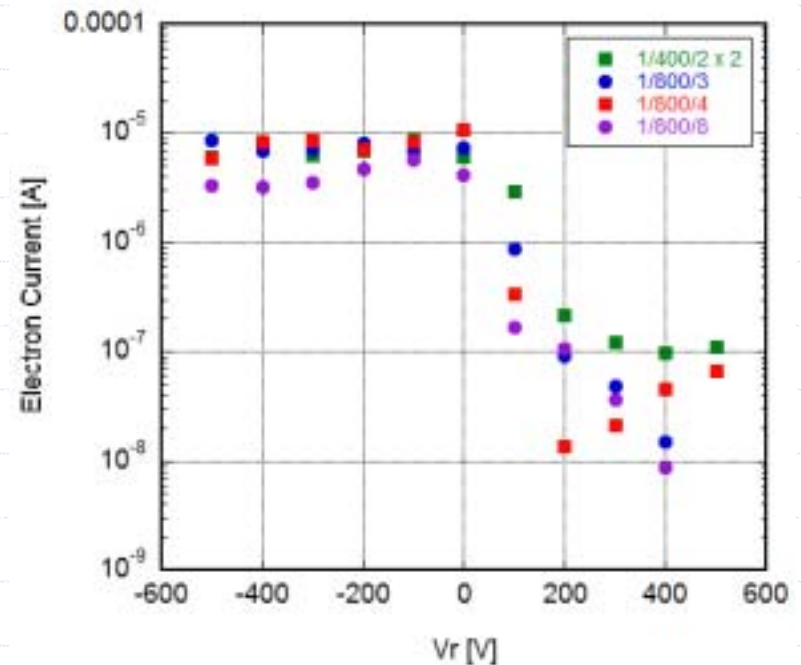
- Measured Electron Current ( $I_e$ ) for different fill patterns

- $V_r = 0$  kV
- $B = 0.75$  T

Measurement



Simulation ( $\delta_{max} = 1.2$ )



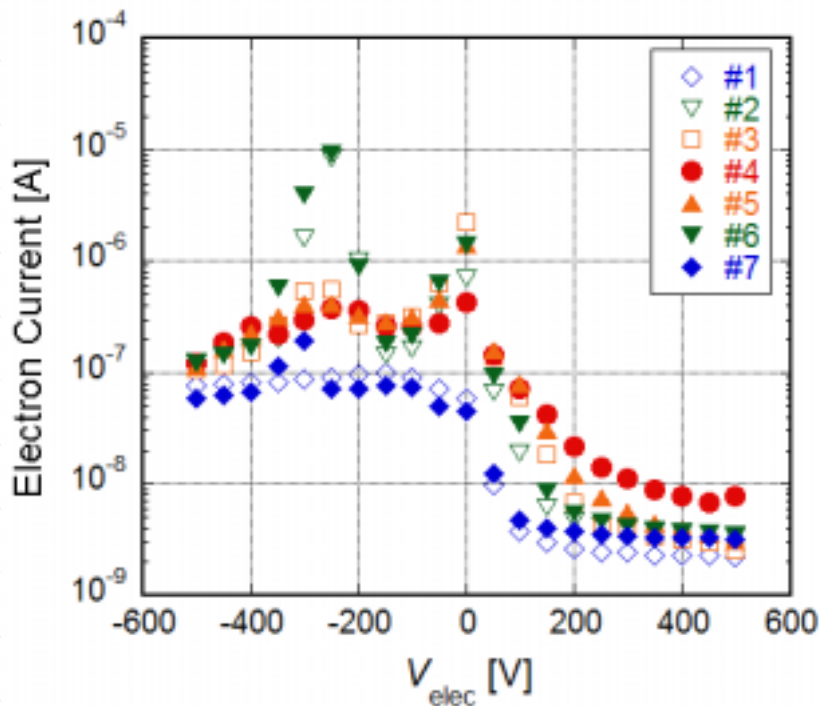
Electrode

# Simulation [Preliminary]

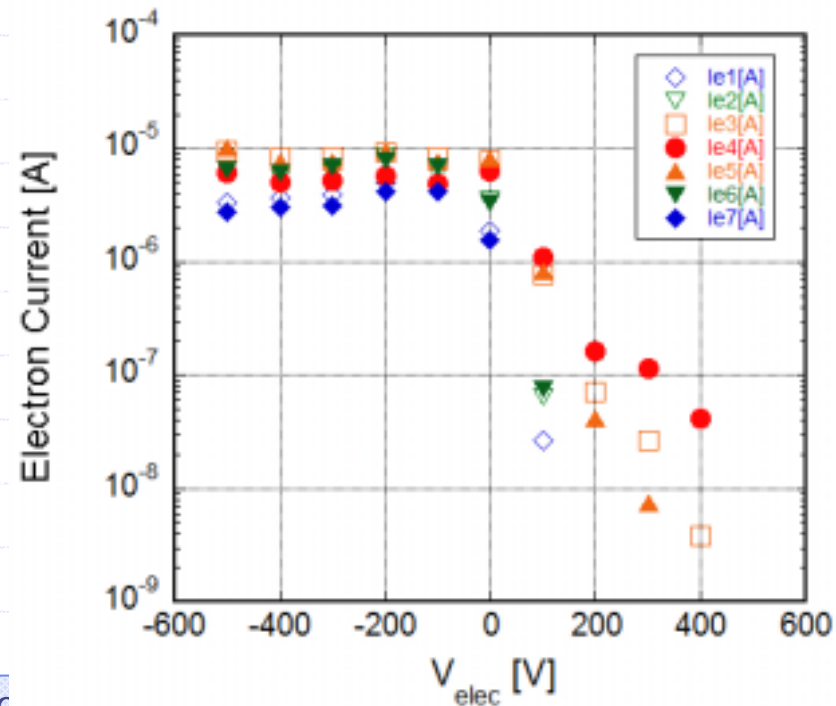
- Spatial distribution of Measured Electron Current ( $I_e$ )

- $V_r = 0$  kV, 4/200/3 (Bs = 6 ns)
- B=0.75 T

Measurement



Simulation ( $\delta_{max} = 1.2$ )



# Note

- model

